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Pyon(10) **Pub. No.: US 2016/0118452 A1**(43) **Pub. Date: Apr. 28, 2016**(54) **ORGANIC LIGHT EMITTING DIODE
DISPLAY DEVICE**(71) Applicant: **SAMSUNG DISPLAY CO., LTD.**,
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(57)

ABSTRACT

An organic light emitting diode display device includes: a substrate; a scan line configured to transfer a scan signal; a data line and a driving voltage line configured to transfer a data voltage and a driving voltage, respectively; a switching transistor including a switching drain electrode configured to output the data voltage; a driving transistor including a driving gate electrode connected with the switching drain electrode; a storage capacitor including a first storage electrode connected with the driving gate electrode and a second storage electrode connected with the driving voltage line; and an organic light emitting diode connected with a driving drain electrode of the driving transistor. The storage capacitor includes: a connector in which an edge of the second storage electrode is offset from an edge of the first storage electrode in a direction toward the center of the second storage electrode, and a storage compensator facing the connector.

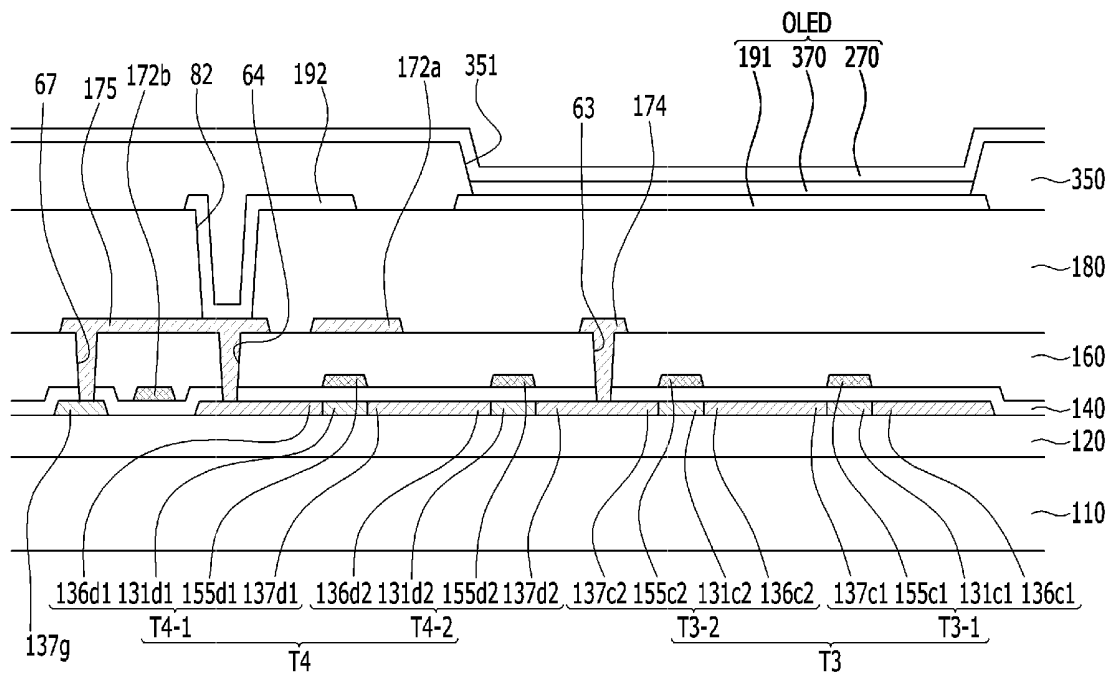


FIG. 1

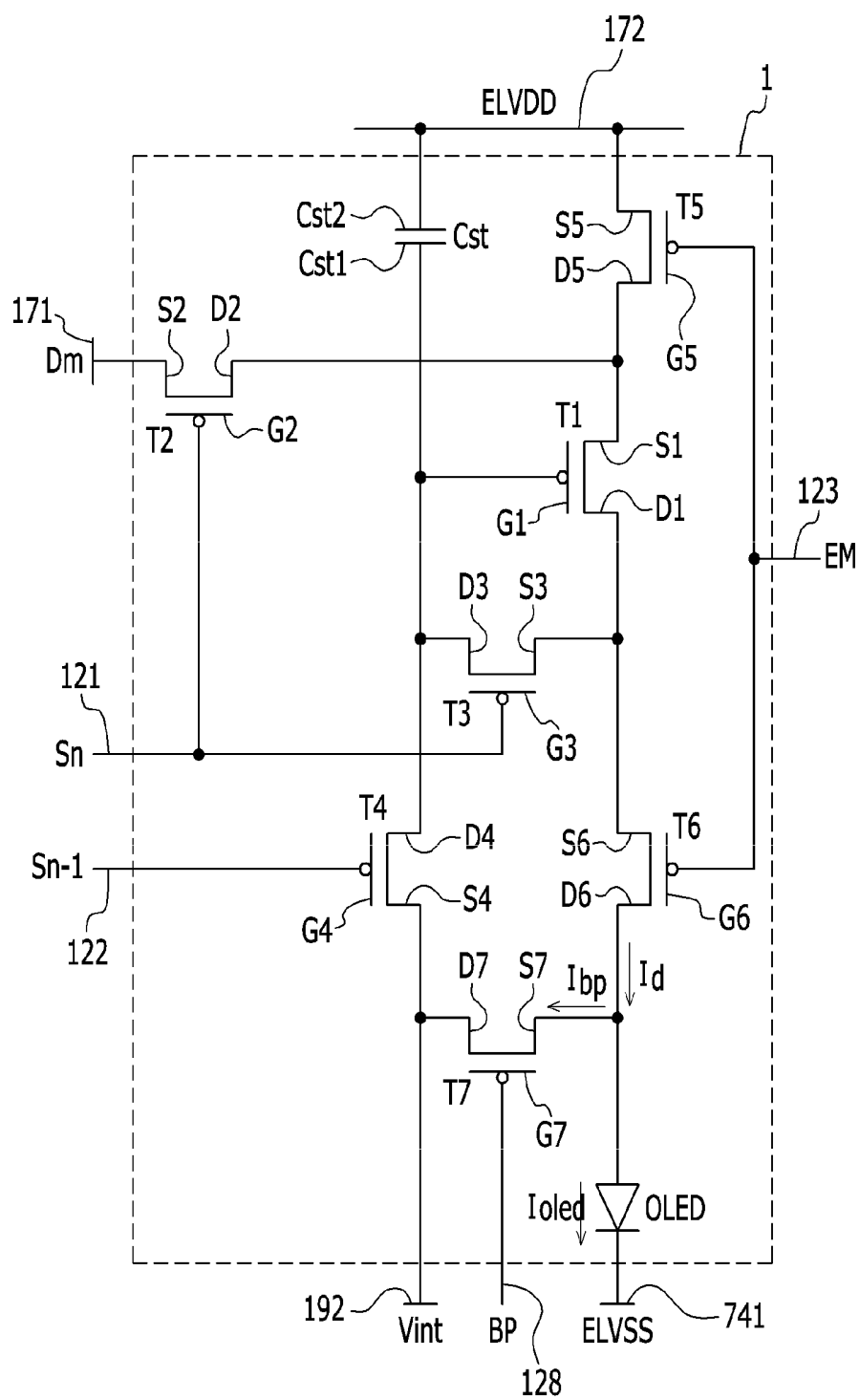


FIG. 2

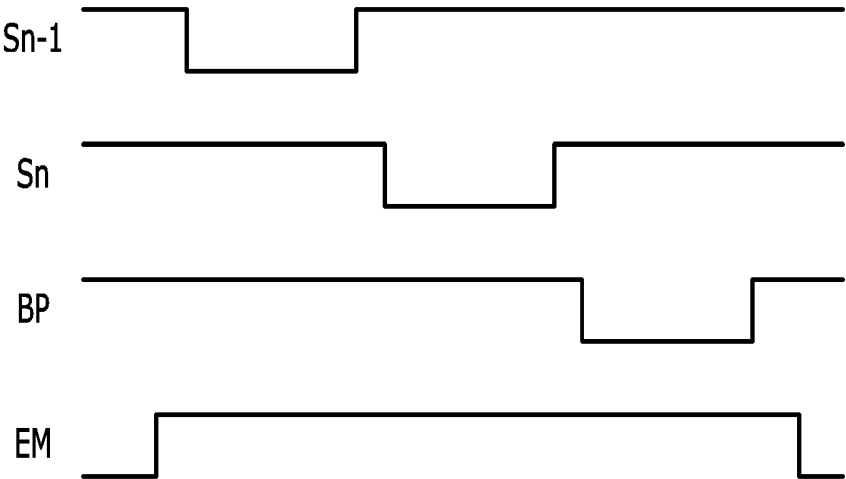


FIG. 4

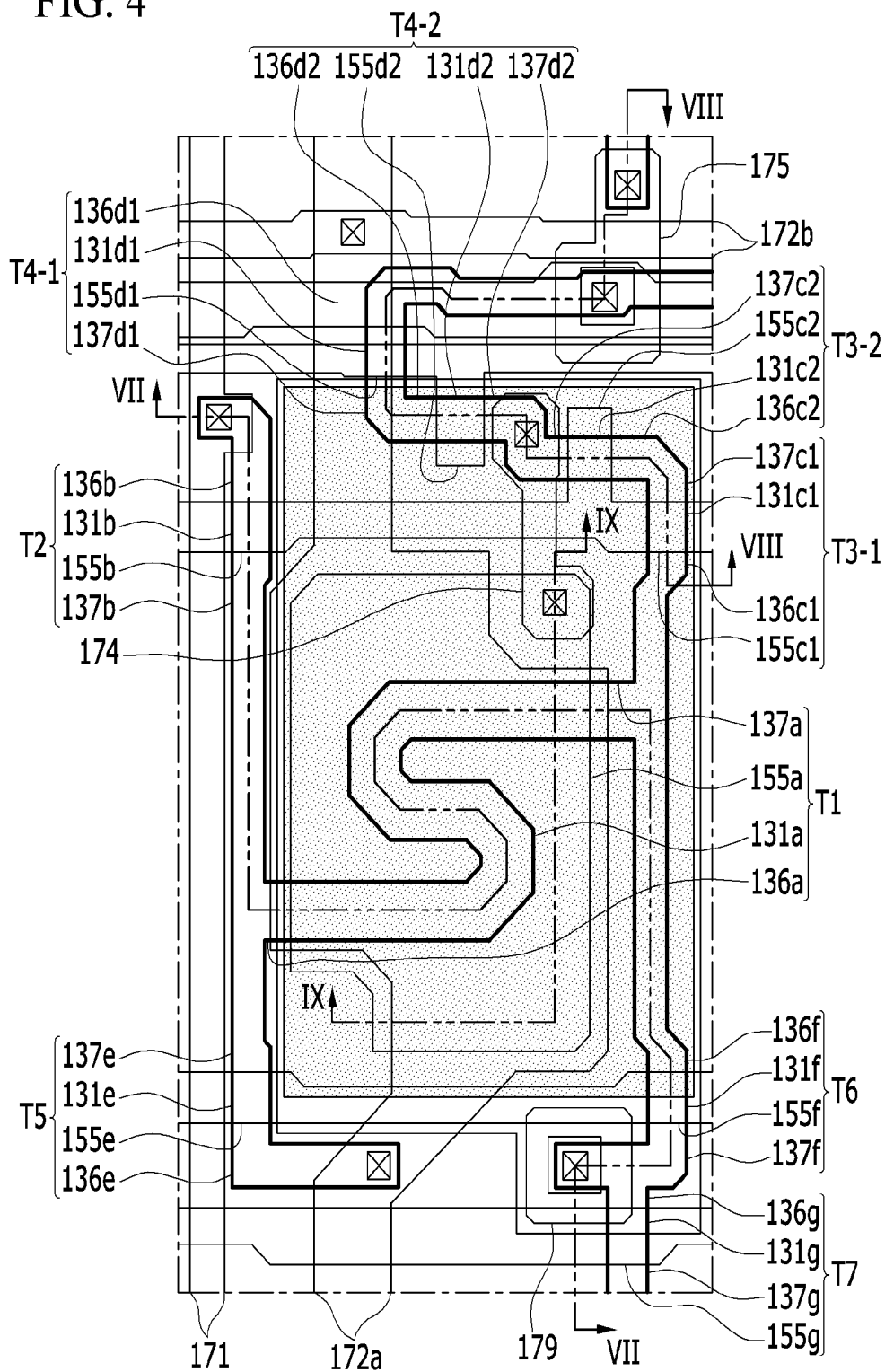


FIG. 5

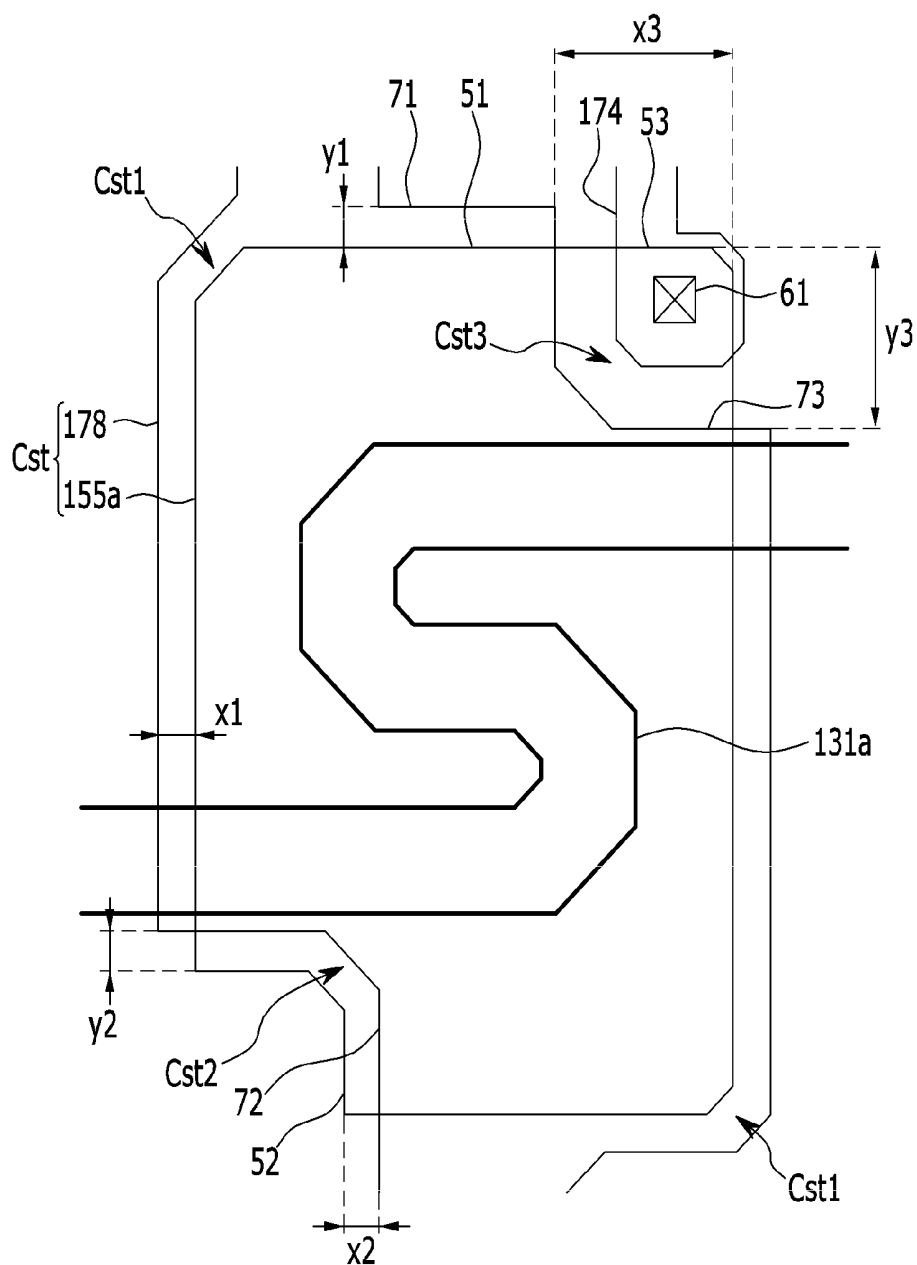


FIG. 6

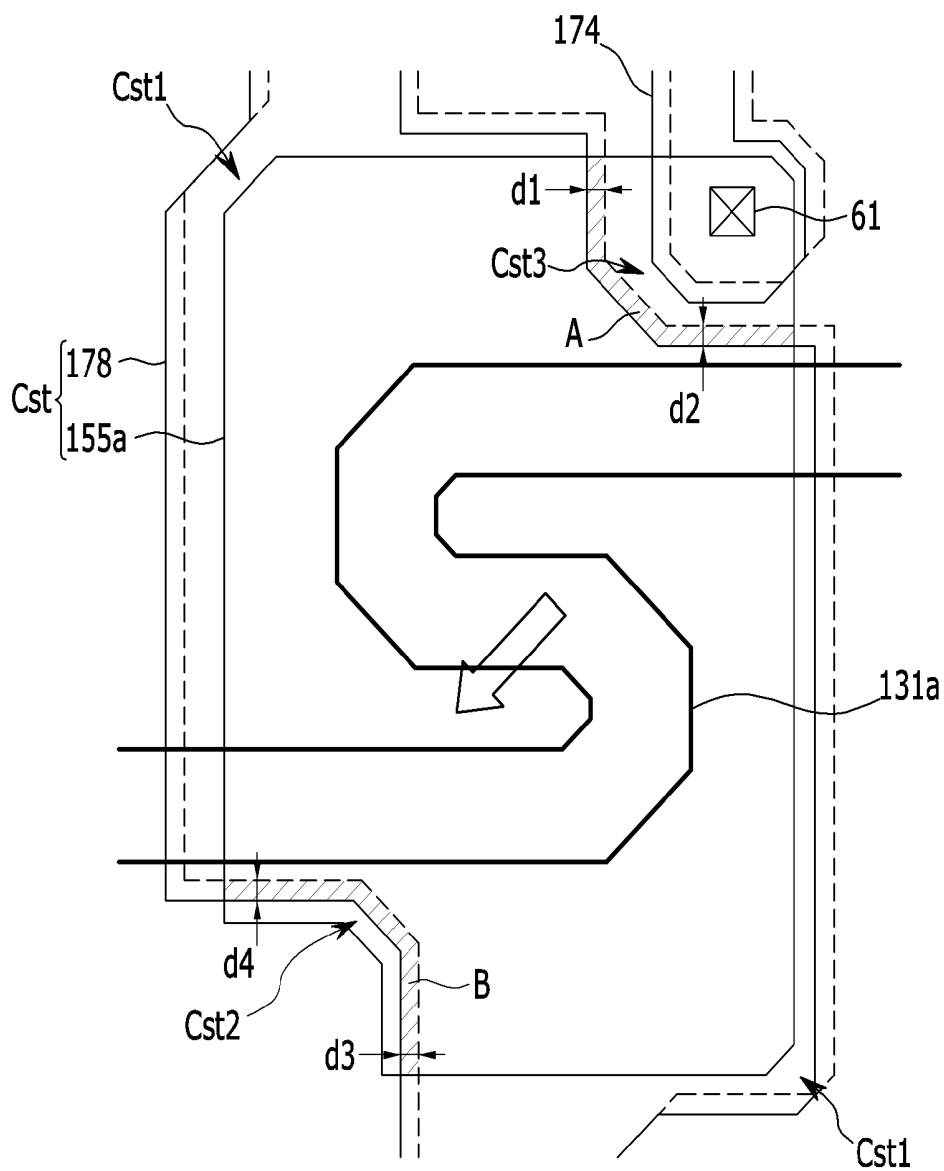


FIG. 8

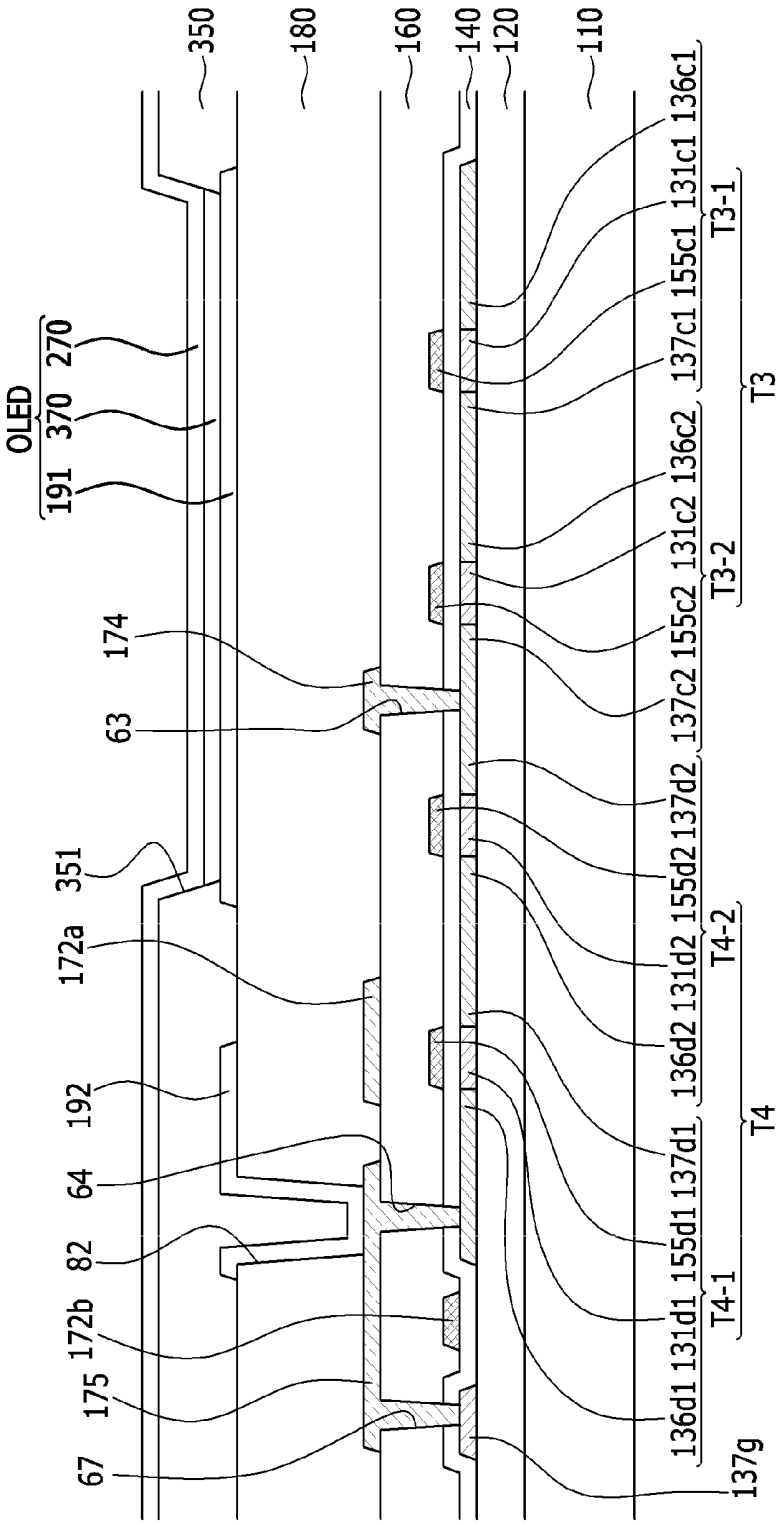


FIG. 9

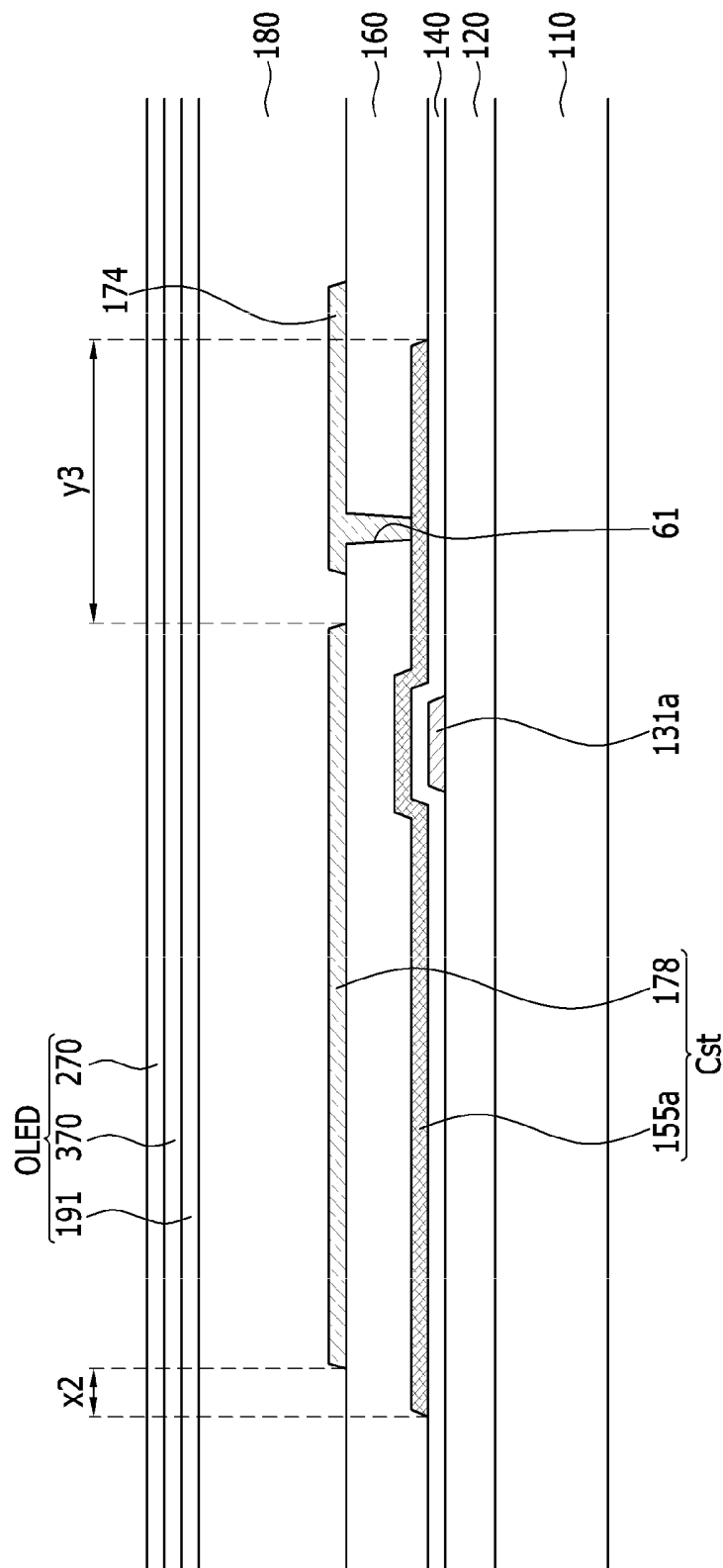


FIG. 10

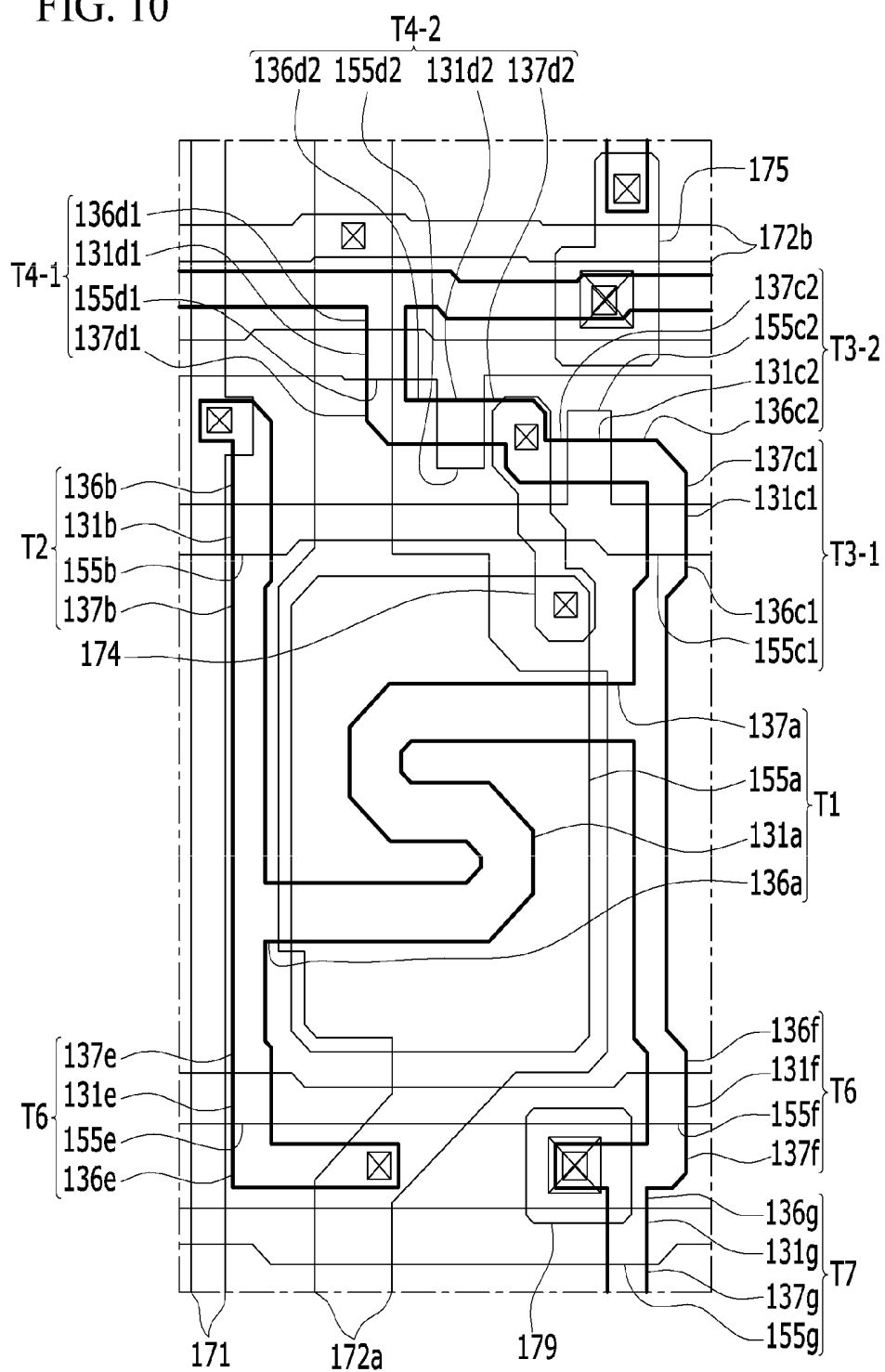


FIG. 11

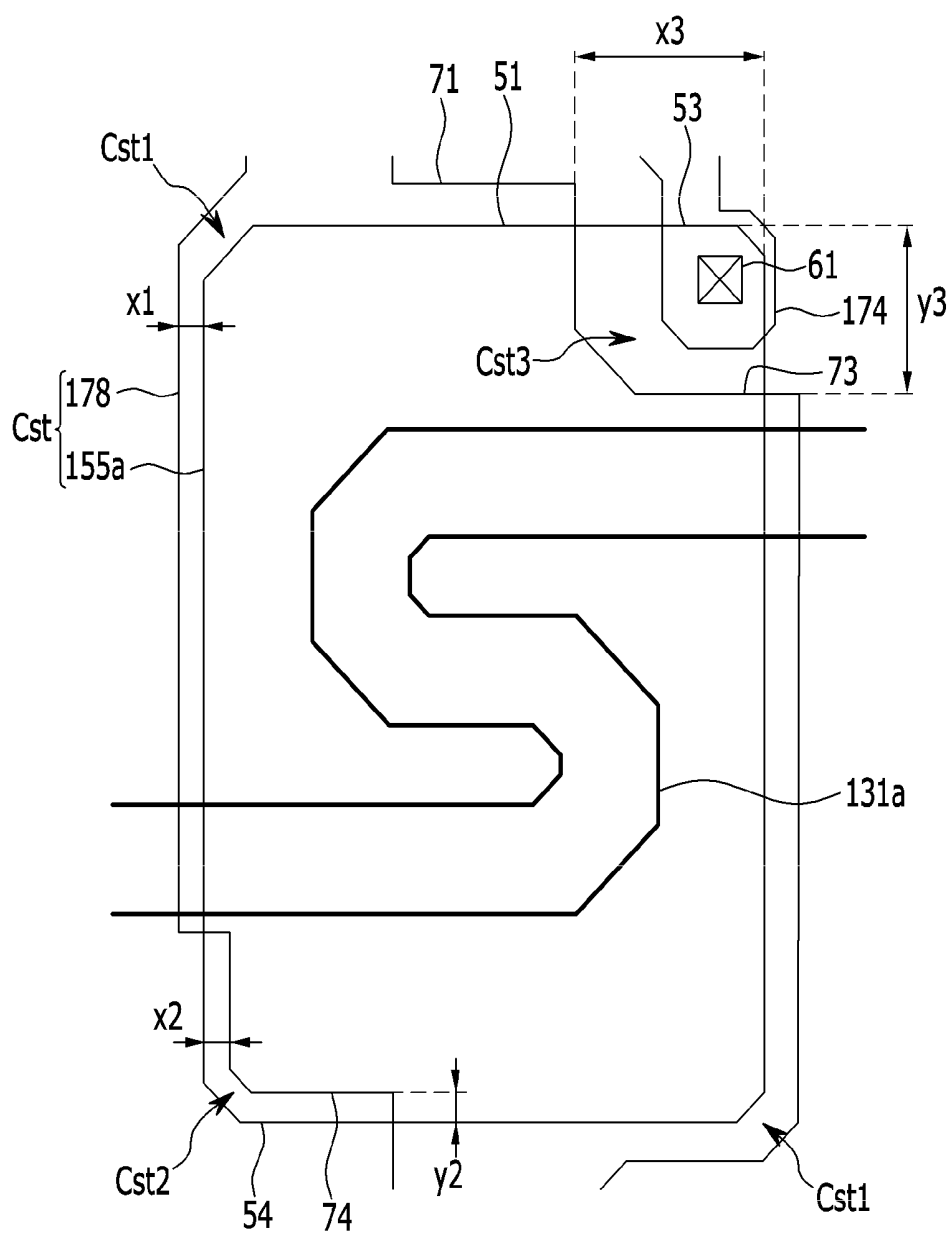


FIG. 12

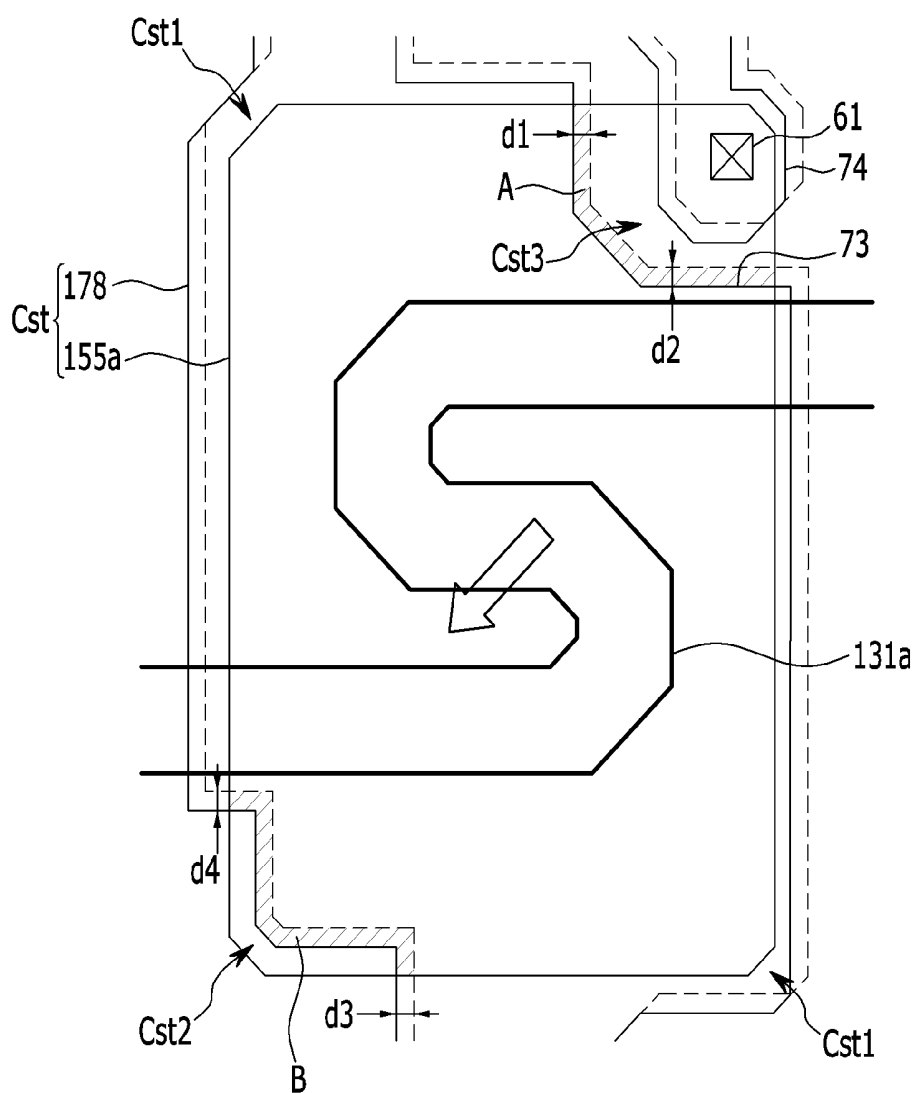


FIG. 13

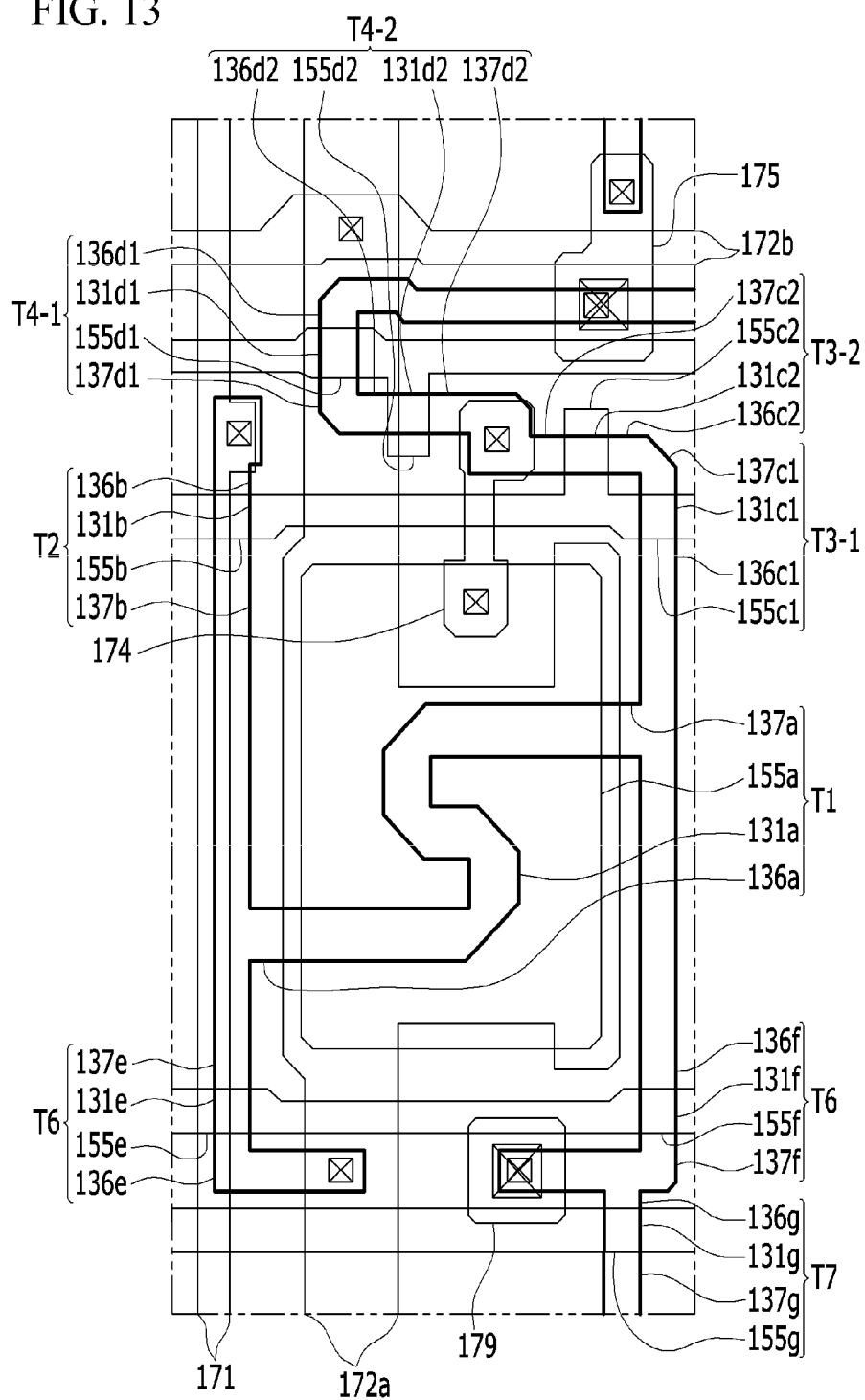
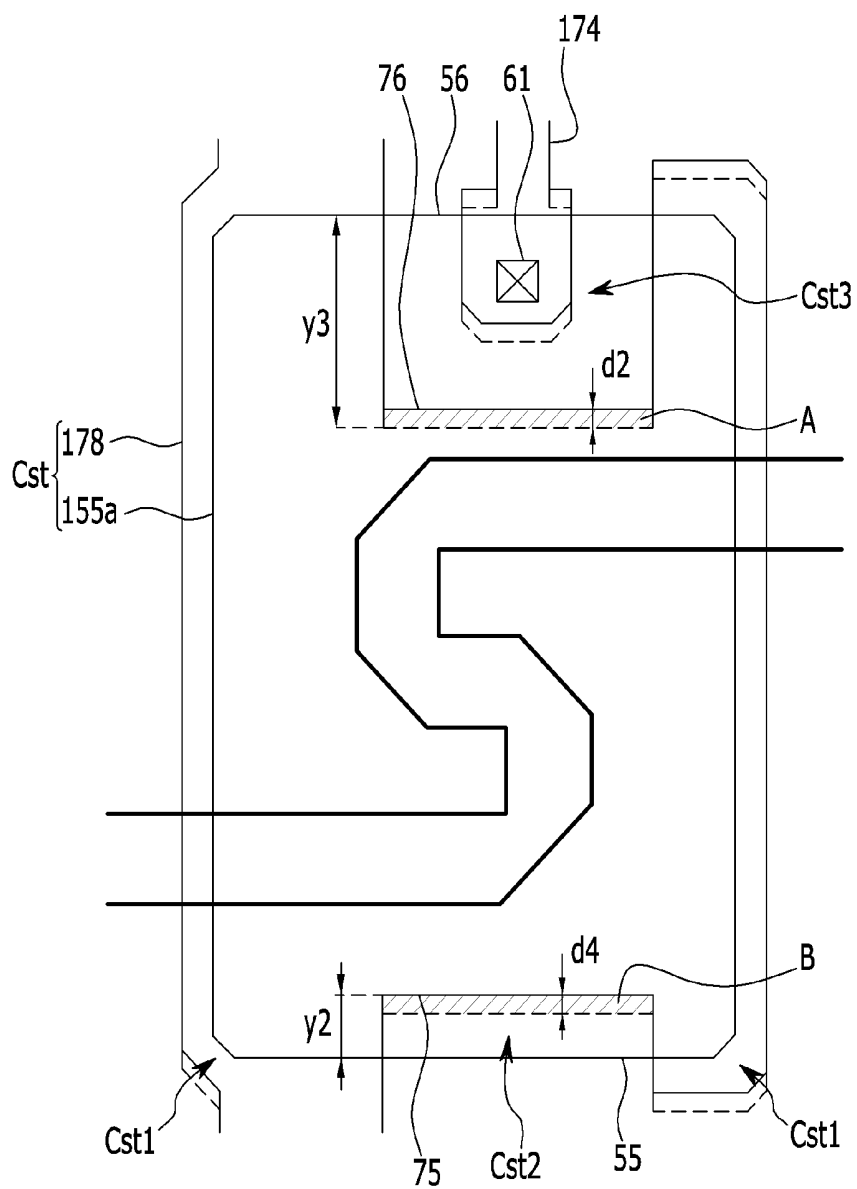


FIG. 14



ORGANIC LIGHT EMITTING DIODE DISPLAY DEVICE

CROSS-REFERENCE TO RELATED APPLICATION

[0001] This application claims priority to and the benefit of Korean Patent Application No. 10-2014-0146468 filed in the Korean Intellectual Property Office on Oct. 27, 2014, the entire contents of which are incorporated herein by reference.

BACKGROUND

[0002] 1. Field

[0003] The present invention relates to an organic light emitting diode display device.

[0004] 2. Description of the Related Art

[0005] An organic light emitting diode includes two electrodes and an organic emission layer positioned therebetween. The organic light emitting diode emits light when electrons injected from one electrode and holes injected from the other electrode are coupled with each other in the organic emission layer to form excitons, and the excitons discharge energy.

[0006] An organic light emitting diode display device includes a plurality of pixels including the organic light emitting diode which is a self-emission element, and in each pixel, a plurality of transistors for driving the organic light emitting diode and one or more capacitors are formed. The plurality of transistors basically includes a switching transistor and a driving transistor.

[0007] A wire pattern of the organic light emitting diode display device may be formed by using a photolithography process. A plurality of lenses of an exposure scanner used in an exposure process which is a part of the photolithography process may overlap with each other at ends thereof, and an exposure amount may be uneven at an overlapping section of the lenses. In this case, the wire pattern may be displaced (e.g., moved by a predetermined distance) from the position (e.g., the predetermined position) of the wire pattern to be formed, and an overlay change in which an overlapping distance from wires formed therebelow or thereon may occur. According to the overlay change, the storage capacitance may be changed, and as a result, a current flowing in the pixel is nonuniform and spots may be generated.

[0008] The above information disclosed in this Background section is only for enhancement of understanding of the background of the invention and therefore it may contain information that does not form the prior art already known in this country to a person of ordinary skill in the art.

SUMMARY

[0009] Aspects of the present invention provide an organic light emitting diode display device that can reduce (or prevent) spots due to an overlay change.

[0010] An exemplary embodiment of the present disclosure provides an organic light emitting diode display device, including: a substrate; a scan line on the substrate and configured to transfer a scan signal; a data line and a driving voltage line crossing the scan line and configured to transfer a data voltage and a driving voltage, respectively; a switching transistor connected with the scan line and the data line and including a switching drain electrode configured to output the data voltage; a driving transistor including a driving gate electrode connected with the switching drain electrode; a

storage capacitor including a first storage electrode connected with the driving gate electrode and a second storage electrode connected with the driving voltage line; and an organic light emitting diode electrically connected with a driving drain electrode of the driving transistor. The storage capacitor includes: a connector in which an edge of the second storage electrode is offset from an edge of the first storage electrode in a direction toward the center of the second storage electrode, and a storage compensator facing the connector.

[0011] The storage capacitor may further include a main portion in which the edge of the second storage electrode is apart from the edge of the first storage electrode by a main margin width to be offset from the edge of the first storage electrode in a direction away from the center of the second storage electrode, and in the storage compensator, the edge of the second storage electrode may be apart from the edge of the first storage electrode by a compensation margin width to be offset from the edge of the first storage electrode in a direction toward the center of the second storage electrode.

[0012] The main margin width may be a sum of a process margin of the edge of the first storage electrode and a process margin of the edge of the second storage electrode.

[0013] The compensation margin width may have a range from a width smaller than 1% of the main margin width to the same width as the main margin width.

[0014] The storage compensator may include a first corner cut portion of the first storage electrode and a second corner cut portion of the second storage electrode.

[0015] The second corner cut portion may be apart from the first corner cut portion by the compensation margin width to be offset from the first corner cut portion in a direction toward the center of the second storage electrode.

[0016] The storage compensator may face the connector on a diagonal line.

[0017] The storage compensator may include a first corner of the first storage electrode and a second corner of the second storage electrode.

[0018] The second corner may be apart from the first corner by the compensation margin width to be offset from the first corner in a direction toward the center of the second storage electrode.

[0019] The storage compensator may include a first side of the first storage electrode and a second side of the second storage electrode.

[0020] The second side may be apart from the first side by the compensation margin width to be offset from the first side in a direction toward the center of the second storage electrode.

[0021] The connector may include a third corner of the first storage electrode and a third corner cut portion of the second storage electrode.

[0022] The organic light emitting diode display device may further include: a semiconductor on the substrate and including a switching channel of the switching transistor and a driving channel of the driving transistor which are apart from each other, and the driving channel may overlap with the driving gate electrode.

[0023] The first storage electrode may correspond to the driving gate electrode, and the second storage electrode may be on the same layer as the data line and the driving voltage line.

[0024] The driving channel may have at least one curved portion.

[0025] The organic light emitting diode display device may further include: a compensation transistor including a compensation gate electrode which is a part of the scan line, and a compensation source electrode and a compensation drain electrode in the semiconductor; and a first data connector on the same layer as the data line and connecting the first storage electrode and the compensation drain electrode.

[0026] The first data connector may be connected with the third corner of the first storage electrode.

[0027] The driving voltage line may include a first driving voltage line parallel with the data line and a second driving voltage line crossing the data line, and the first driving voltage line may be on the same layer as the data line, and the second driving voltage line may be on the same layer as the scan line.

[0028] According to the exemplary embodiment of the present disclosure, by forming the storage compensation unit positioned in the storage capacitor to face the connection unit, when the first storage electrode or the second storage electrode is formed, even though an overlay change occurs due to nonuniformity of an exposure amount, the storage capacitance may be maintained substantially the same as before.

[0029] Further, the second storage electrode is formed on the same layer with the same material as the driving voltage line and the data line, and as a result, at least one mask may be reduced to manufacture the organic light emitting diode display device.

BRIEF DESCRIPTION OF THE DRAWINGS

[0030] FIG. 1 is an equivalent circuit diagram of one pixel of an organic light emitting diode display device according to an example embodiment of the present invention.

[0031] FIG. 2 is a timing diagram of a signal applied to one pixel in the organic light emitting diode display device according to an example embodiment of the present invention.

[0032] FIG. 3 is a diagram schematically illustrating a plurality of transistors and capacitors in the organic light emitting diode display device according to an example embodiment of the present invention.

[0033] FIG. 4 is a detailed layout view of FIG. 3.

[0034] FIG. 5 is an enlarged layout view illustrating the storage capacitor of FIG. 4.

[0035] FIG. 6 is an enlarged layout view illustrating the storage capacitor when an overlay change of a second storage electrode occurs in the organic light emitting diode display device according to an example embodiment of the present invention.

[0036] FIG. 7 is a cross-sectional view of the organic light emitting diode display device of FIG. 4 taken along the line VII-VII.

[0037] FIG. 8 is a cross-sectional view of the organic light emitting diode display device of FIG. 4 taken along the line VIII-VIII.

[0038] FIG. 9 is a cross-sectional view of the organic light emitting diode display device of FIG. 4 taken along line IX-IX.

[0039] FIG. 10 is a layout view of an organic light emitting diode display device according to another example embodiment of the present invention.

[0040] FIG. 11 is an enlarged layout view illustrating a storage capacitor of FIG. 10.

[0041] FIG. 12 is an enlarged layout view illustrating the storage capacitor when an overlay change of a second storage electrode occurs in FIG. 11.

[0042] FIG. 13 is a layout view of an organic light emitting diode display device according to yet another example embodiment of the present invention.

[0043] FIG. 14 is an enlarged layout view illustrating the storage capacitor when an overlay change of a second storage electrode occurs in FIG. 13.

DETAILED DESCRIPTION

[0044] Hereinafter, example embodiments will be described in more detail with reference to the accompanying drawings, in which like reference numbers refer to like elements throughout. The present invention, however, may be embodied in various different forms, and should not be construed as being limited to only the illustrated embodiments herein. Rather, these embodiments are provided as examples so that this disclosure will be thorough and complete, and will fully convey the aspects and features of the present invention to those skilled in the art. Accordingly, processes, elements, and techniques that are not necessary to those having ordinary skill in the art for a complete understanding of the aspects and features of the present invention may not be described. Unless otherwise noted, like reference numerals denote like elements throughout the attached drawings and the written description, and thus, descriptions thereof will not be repeated. In the drawings, the relative sizes and thicknesses of elements, layers, films, panels, and regions may be exaggerated for clarity. Accordingly, the drawings and description are to be regarded as illustrative in nature and not restrictive.

[0045] It will be understood that, although the terms “first,” “second,” “third,” etc., may be used herein to describe various elements, components, regions, layers and/or sections, these elements, components, regions, layers and/or sections should not be limited by these terms. These terms are used to distinguish one element, component, region, layer or section from another element, component, region, layer or section. Thus, a first element, component, region, layer or section described below could be termed a second element, component, region, layer or section, without departing from the spirit and scope of the present invention.

[0046] Spatially relative terms, such as “beneath,” “below,” “lower,” “under,” “above,” “upper,” and the like, may be used herein for ease of explanation to describe one element or feature’s relationship to another element(s) or feature(s) as illustrated in the figures. It will be understood that the spatially relative terms are intended to encompass different orientations of the device in use or in operation, in addition to the orientation depicted in the figures. For example, if the device in the figures is turned over, elements described as “below” or “beneath” or “under” other elements or features would then be oriented “above” the other elements or features. Thus, the example terms “below” and “under” can encompass both an orientation of above and below. The device may be otherwise oriented (e.g., rotated 90 degrees or at other orientations) and the spatially relative descriptors used herein should be interpreted accordingly.

[0047] It will be understood that when an element or layer is referred to as being “on,” “connected to,” “coupled to,” or “connected with” another element or layer, it can be directly on, connected to, coupled to, or connected with the other element or layer, or one or more intervening elements or layers may be present. In addition, it will also be understood that when an element or layer is referred to as being “between” two elements or layers, it can be the only element

or layer between the two elements or layers, or one or more intervening elements or layers may also be present.

[0048] The terminology used herein is for the purpose of describing particular embodiments only and is not intended to be limiting of the present invention. As used herein, the singular forms “a” and “an” are intended to include the plural forms as well, unless the context clearly indicates otherwise. It will be further understood that the terms “comprises,” “comprising,” “includes,” and “including,” when used in this specification, specify the presence of the stated features, integers, steps, operations, elements, and/or components, but do not preclude the presence or addition of one or more other features, integers, steps, operations, elements, components, and/or groups thereof. As used herein, the term “and/or” includes any and all combinations of one or more of the associated listed items. Expressions such as “at least one of,” when preceding a list of elements, modify the entire list of elements and do not modify the individual elements of the list.

[0049] As used herein, the term “substantially,” “about,” and similar terms are used as terms of approximation and not as terms of degree, and are intended to account for the inherent deviations in measured or calculated values that would be recognized by those of ordinary skill in the art. Further, the use of “may” when describing embodiments of the present invention refers to “one or more embodiments of the present invention.” As used herein, the terms “use,” “using,” and “used” may be considered synonymous with the terms “utilize,” “utilizing,” and “utilized,” respectively. Also, the term “exemplary” is intended to refer to an example or illustration.

[0050] It will be understood that when an element or layer is referred to as being “on,” “connected to,” or “coupled to” another element or layer, it can be directly on, connected to, or coupled to the other element or layer, or one or more intervening elements or layers may be present. Further, throughout the specification, the word “on” may mean positioning on or below the object portion, but does not essentially mean positioning on the upper side of the object portion based on a gravity direction. In addition, it will also be understood that when an element or layer is referred to as being “between” two elements or layers, it can be the only element or layer between the two elements or layers, or one or more intervening elements or layers may also be present.

[0051] Further, throughout the specification, the word “on a plane” means viewing a target portion from the top, and the word “on a cross section” means viewing a cross section formed by vertically cutting a target portion from the side.

[0052] Unless otherwise defined, all terms (including technical and scientific terms) used herein have the same meaning as commonly understood by one of ordinary skill in the art to which the present invention belongs. It will be further understood that terms, such as those defined in commonly used dictionaries, should be interpreted as having a meaning that is consistent with their meaning in the context of the relevant art and/or the present specification, and should not be interpreted in an idealized or overly formal sense, unless expressly so defined herein.

[0053] The organic light emitting diode display device and/or any other relevant devices or components according to embodiments of the present invention described herein may be implemented utilizing any suitable hardware, firmware (e.g. an application-specific integrated circuit), software, or a suitable combination of software, firmware, and hardware. For example, the various components of the organic light emitting diode display device may be formed on one inte-

grated circuit (IC) chip or on separate IC chips. Further, the various components of the organic light emitting diode display device may be implemented on a flexible printed circuit film, a tape carrier package (TCP), a printed circuit board (PCB), and/or formed on a same substrate. Further, the various components of the organic light emitting diode display device may be a process or thread, running on one or more processors, in one or more computing devices, executing computer program instructions and interacting with other system components for performing the various functionalities described herein. The computer program instructions are stored in a memory which may be implemented in a computing device using a standard memory device, such as, for example, a random access memory (RAM). The computer program instructions may also be stored in other non-transitory computer readable media such as, for example, a CD-ROM, flash drive, or the like. Also, a person of skill in the art should recognize that the functionality of various computing devices may be combined or integrated into a single computing device, or the functionality of a particular computing device may be distributed across one or more other computing devices without departing from the scope of the exemplary embodiments of the present invention.

[0054] Next, an organic light emitting diode display device according to an example embodiment of the present invention will be described in detail with reference to FIGS. 1 to 8.

[0055] FIG. 1 is an equivalent circuit diagram of one pixel of an organic light emitting diode display device according to an example embodiment of the present invention.

[0056] As illustrated in FIG. 1, one pixel 1 of the organic light emitting diode display device according to an example embodiment of the present invention includes a plurality of signal lines 121, 122, 123, 128, 171, 172, and 192, a plurality of transistors T1, T2, T3, T4, T5, T6, and T7 connected to the plurality of signal lines, a storage capacitor Cst, and an organic light emitting diode OLED.

[0057] The transistors T1, T2, T3, T4, T5, T6, and T7 include a driving transistor T1, a switching transistor T2, a compensation transistor T3, an initialization transistor T4, an operation control transistor T5, a light emission control transistor T6, and a bypass transistor T7.

[0058] The signal lines 121, 122, 123, 128, 171, 172, and 192 include a scan line 121 for transferring a scan signal Sn, a previous scan line 122 for transferring a previous scan signal Sn-1 to the initialization transistor T4, a light emission control line 123 for transferring a light emission control signal EM to the operation control transistor T5 and the light emission control transistor T6, a bypass control line 128 for transferring a bypass signal BP to the bypass transistor T7, a data line 171 crossing the scan line 121 and being for transferring a data signal Dm, a driving voltage line 172 for transferring a driving voltage ELVDD and formed to be substantially parallel with the data line 171, and an initialization voltage line 192 for transferring an initialization voltage Vint for initializing the driving transistor T1.

[0059] A gate electrode G1 of the driving transistor T1 is connected with one end Cst1 of the storage capacitor Cst, a source electrode S1 of the driving transistor T1 is connected with the driving voltage line 172 via the operation control transistor T5, a drain electrode D1 of the driving transistor T1 is electrically connected with an anode of the organic light emitting diode OLED via the light emission control transistor T6. The driving transistor T1 receives the data signal Dm

according to a switching operation of the switching transistor T2 to supply a driving current Id to the organic light emitting diode OLED.

[0060] A gate electrode G2 of the switching transistor T2 is connected with the scan line 121, a source electrode S2 of the switching transistor T2 is connected with the data line 171, and a drain electrode D2 of the switching transistor T2 is connected with the source electrode S1 of the driving transistor T1 and connected with the driving voltage line 172 via the operation control transistor T5. The switching transistor T2 is turned on according to the scan signal Sn received through the scan line 121 to perform a switching operation of transferring the data signal Dm transferred to the data line 171 to the source electrode of the driving transistor T1.

[0061] A gate electrode G3 of the compensation transistor T3 is connected with the scan line 121, a source electrode S3 of the compensation transistor T3 is connected with the drain electrode D1 of the driving transistor T1 and connected with an anode of the organic light emitting diode OLED via the light emission control transistor T6, and a drain electrode D3 of the compensation transistor T3 is connected together with the drain electrode D4 of the initialization transistor T4, one end Cst1 of the storage capacitor Cst, and the gate electrode G1 of the driving transistor T1. The compensation transistor T3 is turned on according to the scan signal Sn received through the scan line 121 to connect the gate electrode G1 and the drain electrode D1 of the driving transistor T1 and diode-connect the driving transistor T1.

[0062] A gate electrode G4 of the initialization transistor T4 is connected with the previous scan line 122, a source electrode S4 of the initialization transistor T4 is connected with the initialization voltage line 192, and a drain electrode D4 of the initialization transistor T4 is connected together with one end Cst1 of the storage capacitor Cst and the gate electrode G1 of the driving transistor T1 and the drain electrode D3 of the compensation transistor T3. The initialization transistor T4 is turned on according to the previous scan signal Sn-1 received through the previous scan line 122 to transfer the initialization voltage Vint to the gate electrode G1 of the driving transistor T1 and then perform an initialization operation initializing a gate voltage of the gate electrode G1 of the driving transistor T1.

[0063] A gate electrode G5 of the operation control transistor T5 is connected with the light emission control line 123, a source electrode S5 of the operation control transistor T5 is connected with the driving voltage line 172, and a drain electrode D5 of the operation control transistor T5 is connected with the source electrode S1 of the driving transistor T1 and the drain electrode S2 of the switching transistor T2.

[0064] A gate electrode G6 of the light emission control transistor T6 is connected with the light emission control line 123, a source electrode S6 of the light emission control transistor T6 is connected with the drain electrode D1 of the driving transistor T1 and the source electrode S3 of the compensation transistor T3, and a drain electrode D6 of the light emission control transistor T6 is electrically connected with an anode of the organic light emitting diode OLED. The operation control transistor T5 and the light emission control transistor T6 are concurrently (e.g., simultaneously) turned on according to the light emission control signal EM received through the light emission control line 123, and as a result, the driving voltage ELVDD is compensated through the diode-connected driving transistor T1 to be transferred to the organic light emitting diode OLED.

[0065] A gate electrode G7 of the bypass transistor T7 is connected with the bypass control line 128, a source electrode S7 of the bypass transistor T7 is connected together with the drain electrode D6 of the light emission control transistor T6 and the anode of the organic light emitting diode OLED, and a drain electrode D7 of the bypass transistor T7 is connected together with the initialization voltage line 192 and the source electrode S4 of the initialization transistor T4.

[0066] The other end Cst2 of the storage capacitor Cst is connected with the driving voltage line 172, and a cathode of the organic light emitting diode OLED is connected with a common voltage line 741 transferring a common voltage ELVSS.

[0067] Hereinafter, a detailed operation process of one pixel of the organic light emitting diode display device according to an example embodiment of the present invention will be described in detail with reference to FIG. 2.

[0068] FIG. 2 is a timing diagram of a signal applied to one pixel in the organic light emitting diode display device according to an example embodiment of the present invention.

[0069] As illustrated in FIG. 2, first, for an initialization period, the previous scan signal Sn-1 at a low level is supplied through the previous scan line 122. In this case, the light emission control signal EM at a high level is already applied through the light emission control line 123. Then, the initialization transistor T4 is turned on in response to the previous scan signal Sn-1 at the low level, the initialization voltage Vint is connected from the initialization voltage line 192 to the gate electrode G1 of the driving transistor T1 through the initialization transistor T4, and the driving transistor T1 is initialized by the initialization voltage Vint.

[0070] Thereafter, for a data programming period, the scan signal Sn at the low level is supplied through the scan line 121. Then, the switching transistor T2 and the compensation transistor T3 are turned on in response to the scan signal Sn at the low level. In this case, the driving transistor T1 is diode-connected by the turned-on compensation transistor T3 and biased in a forward direction.

[0071] Then, a compensation voltage Dm+Vth (Vth has a negative (-) value) reduced from the data signal Dm supplied from the data line 171 by a threshold voltage Vth of the driving transistor T1 is applied to the gate electrode G1 of the driving transistor T1. The driving voltage ELVDD and the compensation voltage Dm+Vth are applied to respective ends of the storage capacitor Cst, and a charge corresponding to a voltage difference between the two ends is stored in the storage capacitor Cst.

[0072] Thereafter, for the emission period, the light emission control signal EM supplied from the light emission control line 123 is changed from the high level to the low level. Then, for the emission period, the operation control transistor T5 and the light emission control transistor T6 are turned on by the light emission control signal EM at the low level.

[0073] Then, a driving current Id is generated according to a voltage difference between the gate voltage of the gate electrode G1 of the driving transistor T1 and the driving voltage ELVDD, and the driving current Id is supplied to the organic light emitting diode OLED through the light emission control transistor T6. For a light emission period, a gate-source voltage Vgs of the driving transistor T1 is maintained at '(Dm+Vth)-ELVDD' by the storage capacitor Cst, and according to a current-voltage relationship of the driving transistor T1, the driving current Id is proportional to the

square of a value obtained by subtracting the threshold voltage from the source-gate voltage, or $(D_m - ELVDD)^2$. Accordingly, the driving current I_d is determined regardless of the threshold voltage V_{th} of the driving transistor T1.

[0074] In one embodiment, the bypass transistor T7 receives the bypass signal BP from the bypass control line 128. Thus a part of the driving current I_d flows out through the bypass transistor T7 as a bypass current I_{bp} .

[0075] Even in the case where a minimum current of the driving transistor T1 for displaying a black image flows as the driving current, when the organic light emitting diode OLED emits light, the black image may not be displayed well. Accordingly, the bypass transistor T7 of the organic light emitting diode display device according to an example embodiment of the present invention may distribute a part of the minimum current of the driving transistor T1 as the bypass current I_{bp} to another current path other than the current path of the organic light emitting diode side. Here, the minimum current of the driving transistor T1 refers to a current under a condition in which the driving transistor T1 is turned off because the gate-source voltage V_{gs} of the driving transistor T1 is smaller than the threshold voltage V_{th} . The minimum driving current (for example, a current of 10 pA or less) under the condition in which the driving transistor T1 is turned off is transferred to the organic light emitting diode OLED to be expressed as an image with black luminance. When the minimum driving current for expressing the black image flows, an influence on a bypass transfer of the bypass current I_{bp} may be large, but when a large driving current for expressing an image such as a normal image or a white image flows, there may be little influence on the bypass current I_{bp} . Accordingly, when the driving current for displaying a black image flows, the light emission current I_{oled} of the organic light emitting diode OLED which is reduced by the current amount of the bypass current I_{bp} which flows out from the driving current I_d through the bypass transistor T7 has a minimum current amount as a level which may more exactly express the black image. Therefore, a black luminance image may be more exactly implemented by using the bypass transistor T7, thereby improving a contrast ratio. In FIG. 2, the bypass signal BP is substantially the same as a next scan signal S_{n+1} , but is not necessarily limited thereto. Further, in an example embodiment of the present invention, a structure having 7 transistors including the bypass transistor T7 and one capacitor is illustrated, but the present invention is not limited thereto, and the number of transistors and the number of capacitors may be variously modified.

[0076] Next, a detailed structure of the pixel of the organic light emitting diode display device illustrated in FIG. 1 will be described in detail with reference to FIGS. 3 to 9 together with FIG. 1.

[0077] FIG. 3 is a diagram schematically illustrating a plurality of transistors and capacitors in the organic light emitting diode display device according to an example embodiment of the present invention, FIG. 4 is a detailed layout view of FIG. 3, FIG. 5 is an enlarged layout view illustrating the storage capacitor of FIG. 4, FIG. 6 is an enlarged layout view illustrating the storage capacitor when an overlay change of a second storage electrode occurs in the organic light emitting diode display device according to an example embodiment of the present invention, FIG. 7 is a cross-sectional view of the organic light emitting diode display device of FIG. 4 taken along the line VII-VII, FIG. 8 is a cross-sectional view of the organic light emitting diode display device of FIG. 4 taken

along the line VIII-VIII, and FIG. 9 is a cross-sectional view of the organic light emitting diode display device of FIG. 4 taken along the line IX-IX.

[0078] Hereinafter, a detailed planar structure of the organic light emitting diode display device according to an example embodiment of the present invention will be first described in detail with reference to FIGS. 3 to 6 and a detailed cross-sectional structure will be described in detail with reference to FIGS. 7 to 9.

[0079] First, as illustrated in FIG. 3, the organic light emitting diode display device according to an example embodiment of the present invention includes the scan line 121, the previous scan line 122, the light emission control line 123, and the bypass control line 128 which apply the scan signal S_n , the previous scan signal S_{n-1} , the light emission control signal EM, and the bypass signal BP, respectively, and are formed in (e.g., extending in) a row direction, and includes the data line 171 and the driving voltage line 172 which cross the scan line 121, the previous scan line 122, the light emission control line 123, and the bypass control line 128 and apply the data signal D_m and the driving voltage ELVDD to the pixel, respectively. The initialization voltage V_{int} is transferred to the compensation transistor T3 through the initialization voltage line 192. The driving voltage line 172 is configured by a first driving voltage line 172a parallel to the data line 171 and a second driving voltage line 172b parallel to the scan line 121. The first driving voltage line 172a and the second driving voltage line 172b are electrically connected with each other.

[0080] Further, in the pixel, the driving transistor T1, the switching transistor T2, the compensation transistor T3, the initialization transistor T4, the operation control transistor T5, the light emission control transistor T6, the bypass transistor T7, the storage capacitor Cst, and the organic light emitting diode OLED including a pixel electrode 191, an organic emission layer 370, and a common electrode 270 are formed. In one embodiment, the compensation transistor T3 and the initialization transistor T4 are configured as a dual gate structure transistor in order to block a leakage current.

[0081] Channels of the driving transistor T1, the switching transistor T2, the compensation transistor T3, the initialization transistor T4, the operation control transistor T5, the light emission control transistor T6, and the bypass transistor T7 may be formed in one semiconductor 130 connected, and the semiconductor 130 may be formed to be curved in various shapes. The semiconductor 130 may be made of a polycrystalline semiconductor material or an oxide semiconductor material. The oxide semiconductor material may include any one of oxides based on titanium (Ti), hafnium (Hf), zirconium (Zr), aluminum (Al), tantalum (Ta), germanium (Ge), zinc (Zn), gallium (Ga), tin (Sn), or indium (In), and indium-gallium-zinc oxide (InGaZnO4), indium-zinc oxide (Zn—In—O), zinc tin oxide (Zn—Sn—O), indium-gallium oxide (In—Ga—O), indium-tin oxide (In—Sn—O), indium-zirconium oxide (In—Zr—O), indium-zirconium-zinc oxide (In—Zr—Zn—O), indium-zirconium-tin oxide (In—Zr—Sn—O), indium-zirconium-gallium oxide (In—Zr—Ga—O), indium aluminum oxide (In—Al—O), indium-zinc-aluminum oxide (In—Zn—Al—O), indium-tin-aluminum oxide (In—Sn—Al—O), indium-aluminum-gallium oxide (In—Al—Ga—O), indium-tantalum oxide (In—Ta—O), indium-tantalum-zinc oxide (In—Ta—Zn—O), indium-tantalum-tin oxide (In—Ta—Sn—O), indium-tantalum-gallium oxide (In—Ta—Ga—O), indium-germanium oxide (In—Ge—O),

indium-germanium-zinc oxide (In—Ge—Zn—O), indium-germanium-tin oxide (In—Ge—Sn—O), indium-germanium-gallium oxide (In—Ge—Ga—O), titanium-indium-zinc oxide (Ti—In—Zn—O), and hafnium-indium-zinc oxide (Hf—In—Zn—O) which are complex oxides thereof. In the case where the semiconductor 130 is made of the oxide semiconductor material, a separate passivation layer for protecting the oxide semiconductor material which is vulnerable to an external environment such as a high temperature may be added.

[0082] The semiconductor 130 includes a channel 131 which is channel-doped with an N-type impurity or a P-type impurity, and a source doping part and a drain doping part which are formed at respective sides of the channel and doped with an opposite-type doping impurity to the doping impurity doped on the channel. In an example embodiment, the source doping part and the drain doping part correspond to the source electrode and the drain electrode, respectively. The source electrode and the drain electrodes formed in the semiconductor 130 may be formed by doping only the corresponding regions. Further, in the semiconductor 130, a region between source electrodes and drain electrodes of different transistors is doped and thus the source electrode and the drain electrode may be electrically connected to each other.

[0083] As illustrated in FIG. 4, the channel 131 includes a driving channel 131a formed in the drive transistor T1, a switching channel 131b formed in the switching transistor T2, a compensation channel 131c (e.g., a compensation channel 131c including the first compensation channel 131c1 and the second compensation channel 131c2) formed in the compensation transistor T3, an initialization channel 131d (e.g., an initialization channel 131d including the first initialization channel 131d1 and the second initialization channel 131d2) formed in the initialization transistor T4, an operation control channel 131e formed in the operation control transistor T5, a light emission control channel 131f formed in the light emission control transistor T6, and a bypass channel 131g formed in the bypass transistor T7.

[0084] The drive transistor T1 includes the driving channel 131a, a driving gate electrode 155a, a driving source electrode 136a, and a driving drain electrode 137a. The driving channel 131a is curved and may have a meandering shape or a zigzag shape. As such, by forming the curved driving channel 131a, the driving channel 131a may be formed to be elongated in a narrow space. Accordingly, a driving range of the gate voltage applied to the driving gate electrode 155a is increased by the elongated driving channel 131a. Since the driving range of the gate voltage is increased, a gray level of light emitted from the organic light emitting diode OLED may be controlled (e.g., finely controlled) by changing the magnitude of the gate voltage, and as a result, the resolution of the organic light emitting diode display device may be enhanced and display quality may be improved. Various examples such as 'reverse S', 'S', 'M', and 'W' may be implemented by variously modifying the shape of the driving channel 131a.

[0085] The driving gate electrode 155a overlaps with the driving channel 131a, and the driving source electrode 136a and the driving drain electrode 137a do not overlap with the driving channel 131a.

[0086] The switching transistor T2 includes the switching channel 131b, a switching gate electrode 155b, a switching source electrode 136b, and a switching drain electrode 137b. The switching gate electrode 155b which is a part extended

downward from the scan line 121 overlaps with the switching channel 131b, and the switching source electrode 136b and the switching drain electrode 137b do not overlap with the switching channel 131b. The switching source electrode 136b is connected with the data line 171 through a contact hole 62.

[0087] Two compensation transistors T3 are formed in order to reduce (or prevent) the leakage current and include a first compensation transistor T3-1 and a second compensation transistor T3-2 which are adjacent to each other. The first compensation transistor T3-1 is positioned around the scan line 121, and the second compensation transistor T3-2 is positioned around a projection of the scan line 121. The first compensation transistor T3-1 includes a first compensation channel 131c1, a first compensation gate electrode 155c1, a first compensation source electrode 136c1, and a first compensation drain electrode 137c1, and the second compensation transistor T3-2 includes a second compensation channel 131c2, a second compensation gate electrode 155c2, a second compensation source electrode 136c2, and a second compensation drain electrode 137c2.

[0088] The first compensation gate electrode 155c1 which is a part of the scan line 121 overlaps with the first compensation channel 131c1, and the first compensation source electrode 136c1 and the first compensation drain electrode 137c1 do not overlap with the first compensation channel 131c1. The first compensation source electrode 136c1 is connected with the light emission control source electrode 136f and the driving drain electrode 137a, and the first compensation drain electrode 137c1 is connected with the second compensation source electrode 136c2.

[0089] The second compensation gate electrode 155c2 which is a projection protruding upward from the scan line 121 overlaps with the second compensation channel 131c2, and the second compensation source electrode 136c2 and the second compensation drain electrode 137c2 do not overlap with the second compensation channel 131c2. The second compensation drain electrode 137c2 is connected with a first data connection member (or first data connector) 174 through a contact hole 63.

[0090] Two initialization transistors T4 are formed in order to reduce (or prevent) the leakage current and include a first initialization transistor T4-1 and a second initialization transistor T4-2 which are adjacent to each other. The first initialization transistor T4-1 is positioned around the previous scan line 122, and the second initialization transistor T4-2 is positioned around a projection of the previous scan line 122. The first initialization transistor T4-1 includes a first initialization channel 131d1, a first initialization gate electrode 155d1, a first initialization source electrode 136d1, and a first initialization drain electrode 137d1, and the second initialization transistor T4-2 includes a second initialization channel 131d2, a second initialization gate electrode 155d2, a second initialization source electrode 136d2, and a second initialization drain electrode 137d2.

[0091] The first initialization gate electrode 155d1 which is a part of the previous scan line 122 overlaps with the first initialization channel 131d1, and the first initialization source electrode 136d1 and the first initialization drain electrode 137d1 do not overlap with the first initialization channel 131d1. The first initialization source electrode 136d1 is connected with a second data connection member (or second data connector) 175 through a contact hole 64, and the first initialization drain electrode 137d1 is connected with the second initialization source electrode 136d2.

[0092] The second initialization gate electrode **155d2** which is a projection protruding downward from the previous scan line **122** overlaps with the second initialization channel **131d2**, and the second initialization source electrode **136d2** and the second initialization drain electrode **137d2** do not overlap with the second initialization channel **131d2**. The second initialization drain electrode **137d2** is connected with the first data connection member **174** through the contact hole **63**.

[0093] As such, according to an embodiment the compensation transistor T3 includes two transistors such as the first compensation transistor T3-1 and the second compensation transistor T3-2, the initialization transistor T4 includes two transistors such as the first initialization transistor T4-1 and the second initialization transistor T4-2, and as a result, it is possible to more efficiently reduce (or prevent) the leakage current from being generated by blocking an electron moving path of the semiconductor **130** in the off state.

[0094] The operation control transistor T5 includes an operation control channel **131e**, an operation control gate electrode **155e**, an operation control source electrode **136e**, and an operation control drain electrode **137e**. The operation control gate electrode **155e** which is a part of the light emission control line **123** overlaps with the operation control channel **131e**, and does not overlap with the operation control source electrode **136e** and the operation control drain electrode **137e**. The operation control source electrode **136e** is connected with a part of the driving voltage line **172** through a contact hole **65**.

[0095] The light emission control transistor T6 includes a light emission control channel **131f**, a light emission control gate electrode **155f**, a light emission control source electrode **136f**, and a light emission control drain electrode **137f**. The light emission control gate electrode **155f** which is a part of the light emission control line **123** overlaps with the light emission control channel **131f**, and does not overlap with the light emission control source electrode **136f** and the light emission control drain electrode **137f**. The light emission control drain electrode **137f** is connected with a third data connection member (or third data connector) **179** through a contact hole **66**.

[0096] The bypass transistor T7 includes a bypass channel **131g**, a bypass gate electrode **155g**, a bypass source electrode **136g**, and a bypass drain electrode **137g**. The bypass gate electrode **155g** which is a part of the bypass control line **128** overlaps with the bypass channel **131g** and does not overlap with the bypass source electrode **136g** and the bypass drain electrode **137g**. The bypass source electrode **136g** is directly connected with the light emission control drain electrode **137f**, and the bypass drain electrode **137g** is connected with a second data connection member **175** through a contact hole **67**.

[0097] One end of the driving channel **131a** of the driving transistor T1 is connected with the switching drain electrode **137b** and the operation control drain electrode **137e**, and the other end of the driving channel **131a** is connected with the compensation source electrode **136c** and the light emission control source electrode **136f**.

[0098] The storage capacitor Cst includes a first storage electrode **155a** and a second storage electrode **178** which are disposed with a second insulating layer **160** therebetween. The first storage electrode **155a** corresponds to the driving gate electrode **155a**, and the second storage electrode **178** is an extended region of the first driving voltage line **172a** and

formed one by one for every pixel. In one embodiment, the second insulating layer **160** is a dielectric material, and a storage capacitance is determined by charges stored in storage capacitor Cst and a voltage between the two electrodes **155a** and **178**. As such, the driving gate electrode **155a** is used as the first storage electrode **155a**, and as a result, it is possible to provide (or ensure) a space in which the storage capacitor may be formed using less space because of the driving channel **131a** having a large area in the pixel.

[0099] The first storage electrode **155a** which is the driving gate electrode **155a** is connected with the first data connection member **174** through the contact hole **61**. The first data connection member **174** is formed on the same layer to be substantially parallel to the data line **171** and connects the driving gate electrode **155a** and the second compensation drain electrode **137c2** of the second compensation transistor T3-2, and the second initialization drain electrode **137d2** of the second initialization transistor T4-2.

[0100] Accordingly, the storage capacitor Cst stores a storage capacitance corresponding to a difference between the driving voltage ELVDD transferred to the second storage electrode **178** through the first driving voltage line **172a** and the gate voltage of the driving gate electrode **155a**.

[0101] The storage capacitor Cst may have a substantially rectangular shape on a plane and includes a main unit (or main portion) Cst1, a storage compensation unit (or storage compensator) Cst2, and a connection unit (or connector) Cst3. In FIG. 5, the storage compensation unit Cst2 is formed at a lower left side of the storage capacitor Cst having the rectangular shape, the connection unit Cst3 is formed at an upper right side of the storage capacitor Cst having the rectangular shape, and the main unit Cst1 corresponds to most of the region except for the connection unit Cst3 and the storage compensation unit Cst2. Particularly, the connection unit Cst3 corresponds to a part where the first data connection member **174** is connected with the first storage electrode **155a** through the contact hole **61**.

[0102] As illustrated in FIG. 5, in the main unit Cst1, an edge **71** of the second storage electrode **178** is spaced apart from an edge **51** of the first storage electrode **155a** by main margin widths x_1 and y_1 to be positioned outside the edge **51**. That is, most of the second storage electrode **178** covers the first storage electrode **155a** to maximally provide (or ensure) the storage capacity of the storage capacitor Cst. The main margin widths x_1 and y_1 include a main horizontal margin width x_1 which is a distance between vertical edges and a main vertical margin width y_1 which is a distance between horizontal edges.

[0103] The storage compensation unit Cst2 is positioned to face the connection unit Cst3 on a diagonal line. In storage compensation unit Cst2, an edge **72** of the second storage electrode **178** is spaced apart from an edge **52** of the first storage electrode **155a** by the compensation margin widths x_2 and y_2 to be positioned inside the edge **52** (e.g., offset from the edge **52** of the first storage electrode **155a** in a direction toward the center of the second storage electrode **178**). In detail, the edge of the first storage electrode **155a** of the storage compensation unit Cst2 corresponds to a first corner cut portion **52** which is dented at the corner portion of the first storage electrode **155a** having the substantially rectangular shape, and the edge of the second storage electrode **178** of the storage compensation unit Cst2 corresponds to a second corner cut portion **72** which is dented at the corner portion of the second storage electrode **178** having the substantially rectan-

gular shape. In addition, the second corner cut portion 72 is spaced apart from the first corner cut portion 52 by the compensation margin widths x_2 and y_2 to be positioned inside the first corner cut portion 52 (e.g., offset from the first corner cut portion 52 in a direction toward the center of the second storage electrode 178).

[0104] The compensation margin widths x_2 and y_2 include a compensation horizontal margin width x_2 which is a distance between vertical edges and a compensation vertical margin width y_2 which is a distance between horizontal edges.

[0105] In addition, in the connection unit Cst3, the edge 73 of the second storage electrode 178 is positioned inside the edge 53 of the first storage electrode 155a (e.g., offset from the edge 53 of the first storage electrode 155a in a direction toward the center of the second storage electrode 178). In detail, the edge 53 of the first storage electrode 155a of the connection unit Cst3 corresponds to a third corner 53 of the first storage electrode 155a having the substantially rectangular shape, and the edge 73 of the second storage electrode 178 of the connection unit Cst3 corresponds to a third corner cut portion 73 which is dented at the corner portion of the second storage electrode 178 having the substantially rectangular shape.

[0106] As such, by forming the storage compensation unit Cst2 positioned to face the connection unit Cst3 on the diagonal line, when the first storage electrode 155a and the second storage electrode 178 are formed, even though an overlay change occurs due to nonuniformity of an exposure amount, the storage capacitance may be maintained substantially the same as before.

[0107] Hereinafter, an effect that the storage capacitance is substantially maintained despite the overlay change in the storage capacitor structure of the organic light emitting diode display device according to an example embodiment of the present invention will be described in detail with reference to FIG. 6.

[0108] As illustrated in FIG. 6, when the overlay change of the second storage electrode 178 occurs in a lower left diagonal direction based on a position of the first storage electrode 155a, the third corner cut portion 73 of the second storage electrode 178 of the connection unit Cst3 moves by a distance d_1 in a horizontal direction (e.g., based on an originally predetermined position) and concurrently (e.g., simultaneously) moves by a distance d_2 in a vertical direction. Accordingly, an overlapping area of the first storage electrode 155a and the second storage electrode 178 is decreased by region A and thus the storage capacitance of the connection unit Cst3 is decreased. However, since the second corner cut portion 72 of the second storage electrode 178 of the storage compensation unit Cst2 moves by a distance d_3 in a horizontal direction (e.g., based on an originally predetermined position) and concurrently (e.g., simultaneously) moves by a distance d_4 in a vertical direction, the overlapping area of the first storage electrode 155a and the second storage electrode 178 is increased by region B and thus the storage capacitance of the storage compensation unit Cst2 is increased. As such, the storage capacitance of the storage compensation unit Cst2 is increased by an amount that corresponds to the decreased storage capacitance of the connection unit Cst3, and as a result, there is little or no change in the storage capacitance.

[0109] Further, the main margin widths x_1 and y_1 may correspond to (or may be) a sum of a process margin m_1 of the

edge of the first storage electrode 155a and a process margin m_2 of the edge of the second storage electrode 178.

[0110] In addition, the compensation margin widths x_2 and y_2 may be in a range from a width smaller than 1% of the main margin widths x_1 and y_1 to substantially the same width as the main margin widths x_1 and y_1 . For example, a minimum value of the compensation margin widths x_2 and y_2 may be a difference value between the main margin widths x_1 and y_1 and 1% of the main margin widths x_1 and y_1 , and a maximum value of the compensation margin widths x_2 and y_2 may be substantially the same value as the main margin widths.

[0111] As such, according to an embodiment since the main margin widths are based on a maximum of process margin, the storage capacitance may be substantially maintained (e.g., always maintained) despite the overlay change within the same compensation margin width range as the main margin width.

[0112] In this case, the second driving voltage line 172b is connected with the first driving voltage line 172a through a contact hole 68. As such, in one embodiment the driving voltage line 172 has a mesh structure by connecting the vertical first driving voltage line 172a and the horizontal second driving voltage line 172b to reduce (or prevent) a voltage drop of the driving voltage ELVDD.

[0113] The third data connection member 179 is connected with the pixel electrode 191 through the contact hole 81, and the second data connection member 175 is connected with the initialization voltage line 192 through the contact hole 82.

[0114] Hereinafter, a sectional structure of the organic light emitting diode display device according to an example embodiment of the present invention will be described in detail according to a lamination order with reference to FIGS. 7 to 9.

[0115] In this case, since a lamination structure of the operation control transistor T5 is mostly the same as that of the light emission control transistor T6, a detailed description of the operation control transistor T5 will be omitted.

[0116] A buffer layer 120 may be formed on a substrate 110. The substrate 110 may be formed by insulating substrates made of glass, crystal, ceramic, plastic, and the like. The buffer layer 120 blocks impurities from the substrate 110 during a crystallization process for forming a polycrystalline semiconductor to improve characteristics of the polycrystalline semiconductor and reduce stress applied to the substrate 110.

[0117] On the buffer layer 120, a semiconductor 130 is formed, which includes a driving channel 131a, a switching channel 131b, a compensation channel 131c, an initialization channel 131d, an operation control channel 131e, and a light emission control channel 131f. A driving source electrode 136a and a driving drain electrode 137a are formed on respective sides of the driving channel 131a in the semiconductor 130 and a switching source electrode 136b and a switching drain electrode 137b are formed on respective sides of the switching channel 131b. In addition, a first compensation source electrode 136c1 and a first compensation drain electrode 137c1 are formed on respective sides of a first compensation channel 131c1, a second compensation source electrode 136c2 and a second compensation drain electrode 137c2 are formed on respective sides of a second compensation channel 131c2, a first initialization source electrode 136d1 and a first initialization drain electrode 137d1 are formed on respective sides of a first initialization channel 131d1, and a second initialization source electrode 136d2 and

a second initialization drain electrode **137d2** are formed on respective sides of a second initialization channel **131d2**. In addition, an operation control source electrode **136e** and an operation control drain electrode **137e** are formed on respective sides of the operation control channel **131e** and a light emission control source electrode **136f** and a light emission control drain electrode **137f** are formed on respective sides of the light emission control channel **131f**.

[0118] A first insulating layer **140** covering the semiconductor **130** is formed on semiconductor **130**. On the first insulating layer **140**, gate wires **121**, **122**, **123**, **155a**, **155b**, **155c1**, **155c2**, **155d1**, **155d2**, **155e**, **155f**, and **172b** which include a scan line **121** including a switching gate electrode **155b**, a first compensation gate electrode **155c1**, and a second compensation gate electrode **155c2**, a previous scan line **122** including a first initialization gate electrode **155d1** and a second initialization gate electrode **155d2**, a light emission control line **123** including an operation control gate electrode **155e** and a light emission control gate electrode **155f**, a driving gate electrode (first storage electrode) **155a**, and a second driving voltage line **172b** are formed.

[0119] A second insulating layer **160** covering the gate wires and the first insulating layer **140** is formed on the gate wires **121**, **122**, **123**, **155a**, **155b**, **155c1**, **155c2**, **155d1**, **155d2**, **155e**, **155f**, and **172b** and the first insulating layer **140**. In one embodiment, the first insulating layer **140** and the second insulating layer **160** are made of nitride silicon (SiNx) or silicon oxygen, e.g., silicon dioxide (SiO₂).

[0120] Data wires **171**, **172a**, **174**, **175**, **178**, and **179** which include a data line **171**, a first driving voltage line **172a** including a second storage electrode **178**, a first data connection member **174**, a second data connection member **175**, and a third data connection member **179** are formed on the second insulating layer **160**.

[0121] As such, since the second storage electrode **178** is formed by the same material and on the same layer as the second driving voltage line **172a** and the data line **171**, the second storage electrode **178** need not to be formed on a separate layer and by separate metal, and as a result, the number of masks used during manufacturing may be reduced.

[0122] The data line **171** is connected with the switching source electrode **136b** through contact holes **62** formed on the first insulating layer **140** and the second insulating layer **160**, one end of the first data connection member **174** is connected with the first storage electrode **155a** through contact holes **61** formed on the first insulating layer **140** and the second insulating layer **160**, and the other end of the first data connection member **174** is connected with the second compensation drain electrode **137c2** and the second initialization drain electrode **137d2** through contact holes **63** formed on the first insulating layer **140** and the second insulating layer **160**.

[0123] The second data connection member **175** is connected with the first initialization source electrode **136d1** through contact holes **64** formed on the first insulating layer **140** and the second insulating layer **160** and connected with a bypass drain electrode **137g** through contact holes **67** formed on the first insulating layer **140** and the second insulating layer **160**. The bypass drain electrode **137g** and the first initialization source electrode **136d1** are not directly connected to each other and are indirectly connected to each other through the second data connection member **175** to prevent a transistor from being formed in the vicinity of the second driving voltage line **172b**.

[0124] In addition, a rectangular third data connection member **179** is connected with the light emission control drain electrode **137f** through contact holes **66** formed on the first insulating layer **140** and the second insulating layer **160**.

[0125] A passivation layer **180** covering the data wires and the second insulating layer **160** is formed on the data wires **171**, **172a**, **174**, **175**, **178**, and **179** and the second insulating layer **160**. The passivation layer **180** may be formed by an organic layer. A pixel electrode **191** and an initialization voltage line **192** are formed on the passivation layer **180**. The third data connection member **179** is connected with the pixel electrode **191** through a contact hole **81** formed on the passivation layer **180** and the second data connection member **175** is connected with the initialization voltage line **192** through a contact hole **82** formed on the passivation layer **180**.

[0126] A pixel defined layer (PDL) **350** covering the passivation layer **180**, the initialization voltage line **192**, and the pixel electrode **191** is formed on edges of the passivation layer **180**, the initialization voltage line **192**, and the pixel electrode **191** and the pixel defined layer **350** has a pixel opening **351** that exposes the pixel electrode **191**. The pixel defined layer **350** may be made of resins such as polyacrylates resin and polyimides or silica-series inorganic materials.

[0127] An organic emission layer **370** is formed on the pixel electrode **191** exposed by the pixel opening **351** and a common electrode **270** is formed on the organic emission layer **370**. As such, an organic light emitting diode (OLED) is formed, which includes the pixel electrode **191**, the organic emission layer **370**, and the common electrode **270**.

[0128] In one embodiment, the pixel electrode **191** is an anode which is a hole injection electrode and the common electrode **270** is a cathode which is an electron injection electrode. However, an example embodiment according to the present invention is not necessarily limited thereto and the pixel electrode **191** may be the cathode and the common electrode **270** may be the anode according to a driving method of the organic light emitting diode display device. When holes and electrons are injected into the organic emission layer **370** from the pixel electrode **191** and the common electrode **270**, respectively, excitons formed (or acquired) by combining the injected holes and electrons fall from an excitation state to a ground state, and light is emitted.

[0129] The organic emission layer **370** may be made of a low-molecular organic material (or a low-molecular weight organic material) or a high-molecular organic material (or a high-molecular weight organic material) such as poly 3,4-ethylenedioxythiophene (PEDOT). Further, the organic emission layer **370** may be formed by multiple layers including at least one of an emission layer, a hole injection layer (HIL), a hole transporting layer (HTL), an electron transporting layer (ETL), and an electron injection layer (EIL). In one embodiment, when the organic emission layer **370** includes all of the layers, the hole injection layer is disposed on the pixel electrode **191** which is the positive electrode, and the hole transporting layer, the emission layer, the electron transporting layer, and the electron injection layer are sequentially laminated thereon.

[0130] The organic emission layer **370** may include a red organic emission layer emitting red light, a green organic emission layer emitting green light, and a blue organic emission layer emitting blue light, and the red organic emission layer, the green organic emission layer, and the blue organic emission layer are formed at a red pixel, a green pixel, and a blue pixel, respectively to implement color images.

[0131] Further, in the organic emission layer 370, all of the red organic emission layer, the green organic emission layer, and the blue organic emission layer are together laminated on the red pixel, the green pixel, and the blue pixel and a red color filter, a green color filter, and a blue color filter are formed for each pixel to implement the color images. As another example, a white organic emission layer emitting a white light is formed on all of the red pixel, the green pixel, and the blue pixel and the red color filter, the green color filter, and the blue color filter are formed for each pixel to implement the color images. When the color images are implemented by using the white organic emission layer and the color filters, a deposition mask for depositing the red organic emission layer, the green organic emission layer, and the blue organic emission layer on individual pixels, that is, the red pixel, the green pixel, and the blue pixel, respectively may not be used.

[0132] The white organic emission layer described in another example may be, of course, formed by one organic emission layer and includes even a configuration that may emit white light by laminating a plurality of organic emission layers. As an example, the white organic emission layer may include a configuration that enables the white light to be emitted by combining at least one yellow organic emission layer and at least one blue organic emission layer, a configuration that enables the white light to be emitted by combining at least one cyan organic emission layer and at least one red organic emission layer, a configuration that enables the white light to be emitted by combining at least one magenta organic emission layer and at least one green organic emission layer, and the like.

[0133] A sealing member protecting the organic light emitting diode OLED may be formed on the common electrode 270, and the sealing member may be sealed on the substrate 110 by a sealant and made of various materials including glass, crystal, ceramic, plastic, and metal. Meanwhile, an inorganic layer and an organic layer may be deposited on the common electrode 270 without using the sealant to form a thin-film sealing layer.

[0134] Meanwhile, in an example embodiment, a storage compensation unit is constituted by a first corner cut portion 52 of a first storage electrode and a second corner cut portion 72 of the second storage electrode 178, but another example embodiment is also possible, in which the storage compensation unit is constituted by a first corner of the first storage electrode and a second corner of the second storage electrode in order to maximize the storage capacitance.

[0135] Hereinafter, an organic light emitting diode display device according to another example embodiment of the present invention will be described in detail with reference to FIGS. 10 to 12.

[0136] FIG. 10 is a layout view of an organic light emitting diode display device according to another example embodiment of the present invention, FIG. 11 is an enlarged layout view illustrating a storage capacitor of FIG. 10, and FIG. 12 is an enlarged layout view illustrating a storage capacitor when an overlay change of the second storage electrode occurs in FIG. 11.

[0137] When comparing another example embodiment illustrated in FIGS. 10 to 12 with an example embodiment illustrated in FIGS. 1 to 9, both embodiments are substantially the same as each other except for a difference in structure of the storage compensation unit. Therefore, a duplicated description will be omitted.

[0138] As illustrated in FIGS. 10 and 11, in a storage compensation unit Cst2 of the organic light emitting diode display device according to another example embodiment of the present invention, an edge 74 of the second storage electrode 178 is spaced apart from an edge 54 of the first storage electrode 155a by a compensation margin width x_2 , y_2 to be positioned inside the edge 54 (e.g., offset from the edge 54 in a direction toward the center of the second storage electrode 178). In detail, the edge of the first storage electrode 155a of the storage compensation unit Cst2 corresponds to a first corner 54 of the first storage electrode 155a having a substantially rectangular shape and the edge of the second storage electrode 178 of the storage compensation unit Cst2 corresponds to a second corner 74 of the second storage electrode 178 having the substantially rectangular shape. In addition, the second corner 74 is spaced apart from the first corner 54 by the compensation margin width x_2 , y_2 to be positioned inside the first corner 54 (e.g., offset from the first corner 54 in a direction toward the center of the second storage electrode 178).

[0139] In addition, in a connection unit Cst3, an edge 73 of the second storage electrode 178 is positioned inside an edge 53 of the first storage electrode 155a (e.g., offset from the edge 53 in a direction toward the center of the second storage electrode 178). In detail, the edge 53 of the first storage electrode 155a of the connection unit Cst3 corresponds to a third corner 53 of the first storage electrode 155a having the substantially rectangular shape and the edge 73 of the second storage electrode 178 corresponds to a third corner cut portion 73 which is dented at a corner portion of the second storage electrode 178 having the substantially rectangular shape.

[0140] As such, the storage compensation unit is constituted by a first corner of the first storage electrode and a second corner of the second storage electrode to maximize the storage capacitance as compared with the example embodiment of FIGS. 1 to 9 in which the storage compensation unit is constituted by the first corner cut portion 52 of the first storage electrode and the second corner cut portion 72 of the second storage electrode 178.

[0141] Further, the storage compensation unit positioned while facing the connection unit Cst3 on a diagonal line is formed to maintain the storage capacitance substantially the same as before even in the case where the overlay is changed due to a problem such as a uniform exposure amount when the first storage electrode 155a or the second storage electrode 178 is formed.

[0142] Hereinafter, an effect in which the storage capacitance is substantially maintained in spite of the overlay change in a storage capacitor structure of the organic light emitting diode display device according to another example embodiment of the present invention will be described in detail with reference to FIG. 12.

[0143] As illustrated in FIG. 12, when the overlay change in the second storage electrode 178 occurs in a lower left diagonal direction based on the position of the first storage electrode 155a, the third corner cut portion 73 of the second storage electrode 178 of the connection unit Cst3 moves by a distance d_2 in a vertical direction while moving by a distance d_1 in a horizontal direction (e.g., based on an originally predetermined position). Therefore, an overlapping area between the first storage electrode 155a and the second storage electrode 178 is reduced by region A, and as a result, storage capacitance of the connection unit Cst3 is reduced.

However, since the second corner **74** of the second storage electrode **178** of the storage compensation unit **Cst2** moves by a distance **d4** in the vertical direction while moving by a distance **d3** in the horizontal direction (e.g., based on the originally predetermined position), the overlapping area between the first storage electrode **155a** and the second storage electrode **178** is increased by region **B**, and as a result, storage capacitance of the storage compensation unit **Cst2** is increased. As such, since the storage capacitance is increased in the storage compensation unit **Cst2** by an amount corresponding to the storage capacitance reduced in the connection unit **Cst3**, the storage capacitance is not correspondingly changed.

[0144] Meanwhile, the storage compensation unit is positioned to face the connection unit positioned at the corner in the diagonal line in an example embodiment, but yet another example embodiment is possible, in which when the connection unit is positioned on a side portion, the storage compensation unit is also positioned on the side portion so that the connection unit and the storage compensation unit are facing each other.

[0145] Hereinafter, an organic light emitting diode display device according to yet another example embodiment of the present invention will be described in detail with reference to FIGS. **13** to **14**.

[0146] FIG. **13** is a layout view of an organic light emitting diode display device according to yet another example embodiment of the present invention, and FIG. **14** is an enlarged layout view illustrating the storage capacitor when an overlay change of a second storage electrode occurs in FIG. **13**.

[0147] When comparing yet another example embodiment illustrated in FIGS. **13** to **14** with the example embodiment illustrated in FIGS. **1** to **9**, both example embodiments are substantially the same as each other except for the difference in structure of the storage compensation unit. Therefore, a duplicated description will be omitted.

[0148] As illustrated in FIGS. **13** and **14**, a storage capacitor **Cst** of the organic light emitting diode display device according to yet another example embodiment of the present invention has a substantially rectangular plane shape and includes a main unit **Cst1**, a second compensation unit **Cst2**, and a connection unit **Cst3**. The storage compensation unit **Cst2** is formed at a central lower portion of the rectangular storage capacitor **Cst**, the connection unit **Cst3** is formed at a central upper portion of the rectangular storage capacitor **Cst**, and the main portion **Cst1** corresponds to most of the region other than the connection unit **Cst3** and the storage compensation unit **Cst2**.

[0149] The storage compensation unit **Cst2** is positioned facing the connection unit **Cst3**. In the storage compensation unit **Cst2**, an edge **75** of the second storage electrode **178** is spaced apart from an edge **55** of the first storage electrode **155a** by a compensation margin width **y2** to be positioned inside the edge **55** (e.g., offset from the edge **55** in a direction toward the center of the second storage electrode **178**). In detail, the edge of the first storage electrode **155a** of the storage compensation unit **Cst2** corresponds to a first side portion **55** of the first storage electrode **155a** having the substantially rectangular shape and the edge **75** of the second storage electrode **178** of the storage compensation unit **Cst2** corresponds to a second side portion **75** of the second storage electrode **178** having the substantially rectangular shape. In addition, the second side portion **75** is spaced apart from the

first side portion **55** by the compensation margin width **y2** to be positioned inside the first side portion **55** (e.g., offset from the first side portion **55** in a direction toward the center of the second storage electrode **178**).

[0150] In an example embodiment, the compensation margin width **y2** means only a compensation vertical margin width **y2** which is a gap between horizontal edges.

[0151] In addition, in the connection unit **Cst3**, an edge **76** of the second storage electrode **178** is positioned inside an edge **56** of the first storage electrode **155a** (e.g., offset from the edge **56** in a direction toward the center of the second storage electrode **178**). In detail, the edge **56** of the first storage electrode **155a** of the connection unit **Cst3** corresponds to a third side portion **56** of the first storage electrode **155a** having the substantially rectangular shape and the edge **76** of the second storage electrode **178** corresponds to a fourth side portion **76** of the second storage electrode **178** having the substantially rectangular shape.

[0152] As described above, according to an embodiment, when the connection unit is positioned on the side portion, there is little or no variation in capacitance in the horizontal overlay change and there is a variation in capacitance only in the vertical overlay change to minimize a variation in storage capacitance.

[0153] Further, the storage compensation unit positioned to face the connection unit **Cst3** is formed, and as a result, even when the overlay change occurs due to the problem such as the uniform exposure amount when the first storage electrode **155a** or the second storage electrode **178** is formed, the storage capacitance may be maintained substantially the same as before.

[0154] As illustrated in FIG. **14**, when the overlay change in the second storage electrode **178** occurs in a vertical upper direction based on the position of the first storage electrode **155a**, the fourth side portion **76** of the second storage electrode **178** of the connection unit **Cst3** moves by a distance **d2** in a vertical direction (e.g., based on an originally predetermined position). Therefore, the overlapping area between the first storage electrode **155a** and the second storage electrode **178** is increased by area **A**, and as a result, the storage capacitance of the connection unit **Cst3** is increased. However, since the second side portion **75** of the second storage electrode **178** of the storage compensation unit **Cst2** moves by a distance **d4** in the vertical upper direction (e.g., based on the originally predetermined position), the overlapping area between the first storage electrode **155a** and the second storage electrode **178** is decreased by area **B**, and as a result, storage capacitance of the storage compensation unit **Cst2** is decreased. As described above, since the storage capacitance is decreased in the storage compensation unit **Cst2** by an amount corresponding to the storage capacitance increased in the connection unit **Cst3**, the storage capacitance is not correspondingly changed.

[0155] While this invention has been described in connection with what is presently considered to be practical example embodiments, it is to be understood that the invention is not limited to the disclosed embodiments, but, on the contrary, is intended to cover various modifications and equivalent arrangements included within the spirit and scope of the appended claims and their equivalents.

Description of some of the reference numerals	
121: Scan line	122: Previous scan line
123: Light emission control line	
155a: Driving gate electrode	155b: Switching gate electrode
131a: Driving channel	131b: Switching channel
140: First insulating layer	160: Second insulating layer
171: Data line	172: Driving voltage line
172a: First driving voltage line	172b: Second driving voltage line
180: Passivation layer	191: Pixel electrode
192: Initialization voltage line	270: Common electrode
370: Organic emission layer	

What is claimed is:

1. An organic light emitting diode display device, comprising:

- a substrate;
- a scan line on the substrate and configured to transfer a scan signal;
- a data line and a driving voltage line crossing the scan line and configured to transfer a data voltage and a driving voltage, respectively;
- a switching transistor connected with the scan line and the data line and comprising a switching drain electrode configured to output the data voltage;
- a driving transistor comprising a driving gate electrode connected with the switching drain electrode;
- a storage capacitor comprising a first storage electrode connected with the driving gate electrode and a second storage electrode connected with the driving voltage line; and

an organic light emitting diode electrically connected with a driving drain electrode of the driving transistor,

wherein the storage capacitor comprises:

- a connector in which an edge of the second storage electrode is offset from an edge of the first storage electrode in a direction toward the center of the second storage electrode, and
- a storage compensator facing the connector.

2. The organic light emitting diode display device of claim 1, wherein:

the storage capacitor further comprises a main portion in which the edge of the second storage electrode is apart from the edge of the first storage electrode by a main margin width to be offset from the edge of the first storage electrode in a direction away from the center of the second storage electrode, and

in the storage compensator, the edge of the second storage electrode is apart from the edge of the first storage electrode by a compensation margin width to be offset from the edge of the first storage electrode in a direction toward the center of the second storage electrode.

3. The organic light emitting diode display device of claim 2, wherein:

the main margin width is a sum of a process margin of the edge of the first storage electrode and a process margin of the edge of the second storage electrode.

4. The organic light emitting diode display device of claim 3, wherein:

the compensation margin width has a range from a width smaller than 1% of the main margin width to the same width as the main margin width.

5. The organic light emitting diode display device of claim 2, wherein:

the storage compensator comprises a first corner cut portion of the first storage electrode and a second corner cut portion of the second storage electrode.

6. The organic light emitting diode display device of claim 5, wherein:

the second corner cut portion is apart from the first corner cut portion by the compensation margin width to be offset from the first corner cut portion in a direction toward the center of the second storage electrode.

7. The organic light emitting diode display device of claim 5, wherein:

the storage compensator faces the connector on a diagonal line.

8. The organic light emitting diode display device of claim 2, wherein:

the storage compensator comprises a first corner of the first storage electrode and a second corner of the second storage electrode.

9. The organic light emitting diode display device of claim 8, wherein:

the second corner is apart from the first corner by the compensation margin width to be offset from the first corner in a direction toward the center of the second storage electrode.

10. The organic light emitting diode display device of claim 2, wherein:

the storage compensator comprises a first side of the first storage electrode and a second side of the second storage electrode.

11. The organic light emitting diode display device of claim 10, wherein:

the second side is apart from the first side by the compensation margin width to be offset from the first side in a direction toward the center of the second storage electrode.

12. The organic light emitting diode display device of claim 2, wherein:

the connector comprises a third corner of the first storage electrode and a third corner cut portion of the second storage electrode.

13. The organic light emitting diode display device of claim 12, further comprising:

a semiconductor on the substrate and comprising a switching channel of the switching transistor and a driving channel of the driving transistor which are apart from each other,

wherein the driving channel overlaps with the driving gate electrode.

14. The organic light emitting diode display device of claim 13, wherein:

the first storage electrode corresponds to the driving gate electrode, and the second storage electrode is on the same layer as the data line and the driving voltage line.

15. The organic light emitting diode display device of claim 13, wherein:

the driving channel has at least one curved portion.

16. The organic light emitting diode display device of claim 13, further comprising:

a compensation transistor comprising a compensation gate electrode which is a part of the scan line, and a compensation source electrode and a compensation drain electrode in the semiconductor; and

a first data connector on the same layer as the data line and connecting the first storage electrode and the compensation drain electrode.

17. The organic light emitting diode display device of claim **16**, wherein:

the first data connector is connected with the third corner of the first storage electrode.

18. The organic light emitting diode display device of claim **2**, wherein:

the driving voltage line comprises a first driving voltage line parallel with the data line and a second driving voltage line crossing the data line, and

the first driving voltage line is on the same layer as the data line, and the second driving voltage line is on the same layer as the scan line.

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专利名称(译)	有机发光二极管显示装置		
公开(公告)号	US20160118452A1	公开(公告)日	2016-04-28
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[标]申请(专利权)人(译)	三星显示有限公司		
申请(专利权)人(译)	三星DISPLAY CO. , LTD.		
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摘要(译)

一种有机发光二极管显示装置，包括：基板；扫描线，用于传输扫描信号；数据线和驱动电压线，分别用于传输数据电压和驱动电压；开关晶体管，包括用于输出数据电压的开关漏电极；驱动晶体管，包括与开关漏电极连接的驱动栅电极；存储电容器，包括与驱动栅电极连接的第一存储电极和与驱动电压线连接的第二存储电极；有机发光二极管，与驱动晶体管的驱动漏极连接。存储电容器包括：连接器，其中第二存储电极的边缘在朝向第二存储电极的中心的的方向上偏离第一存储电极的边缘，以及面向连接器的存储补偿器。

trode; a storage capacitor including a first storage electrode connected with the driving gate electrode and a second storage electrode connected with the driving voltage line; and an organic light emitting diode connected with a driving drain